

On-stage solar cell degradation process: DLTS and LT-PL-EL study

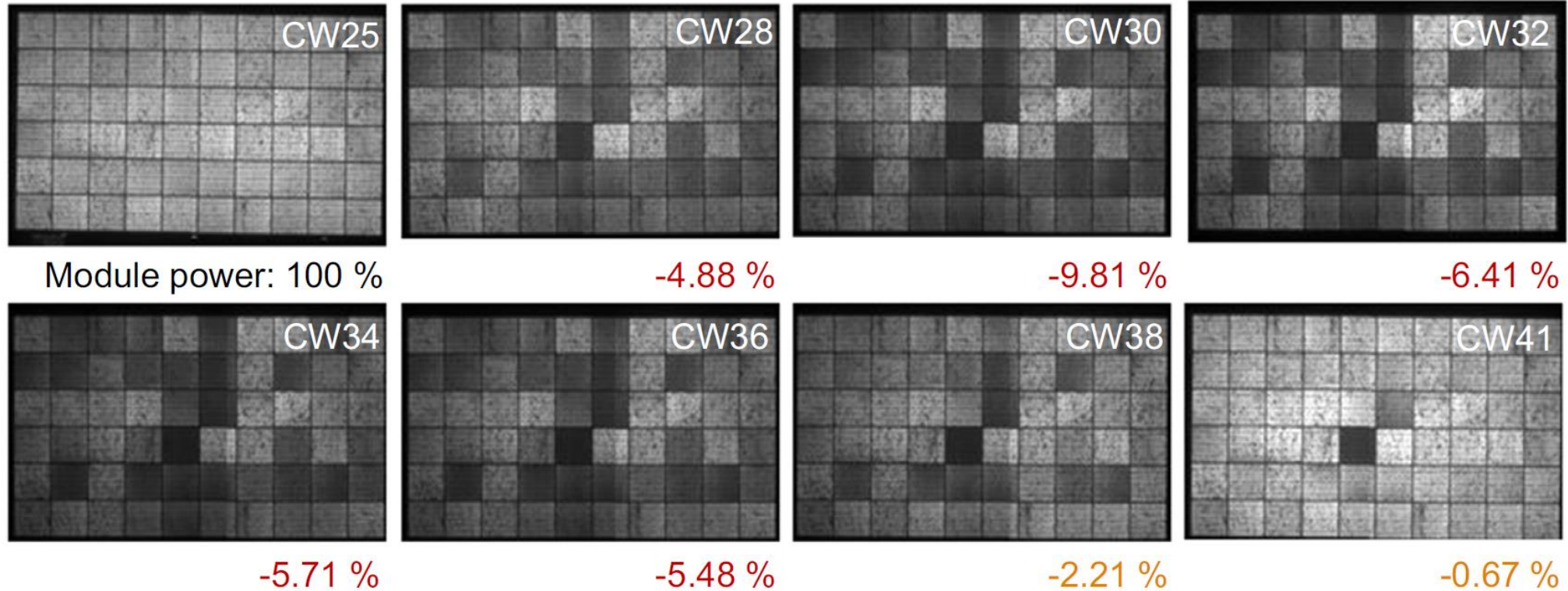


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Light and elevated Temperature Induced Degradation^[1, 2, 3] : (LeTID)^[3]



[3]

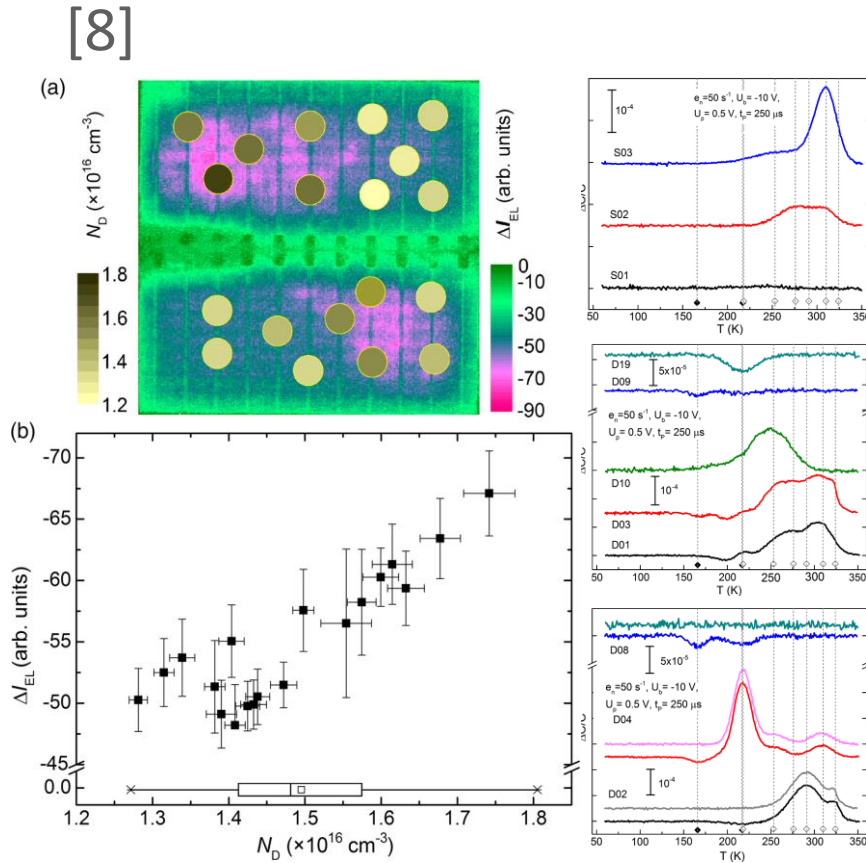
EL and module power measurement (STC) sequence showing the degradation–regeneration cycle and the time-resolved contribution of single cells. “CW” is for a Calendar Week.

- [1] K. Ramspeck, et al., **2012**
- [2] F. Fertig, et al., **2015**
- [3] F. Kersten, et al., **2015**

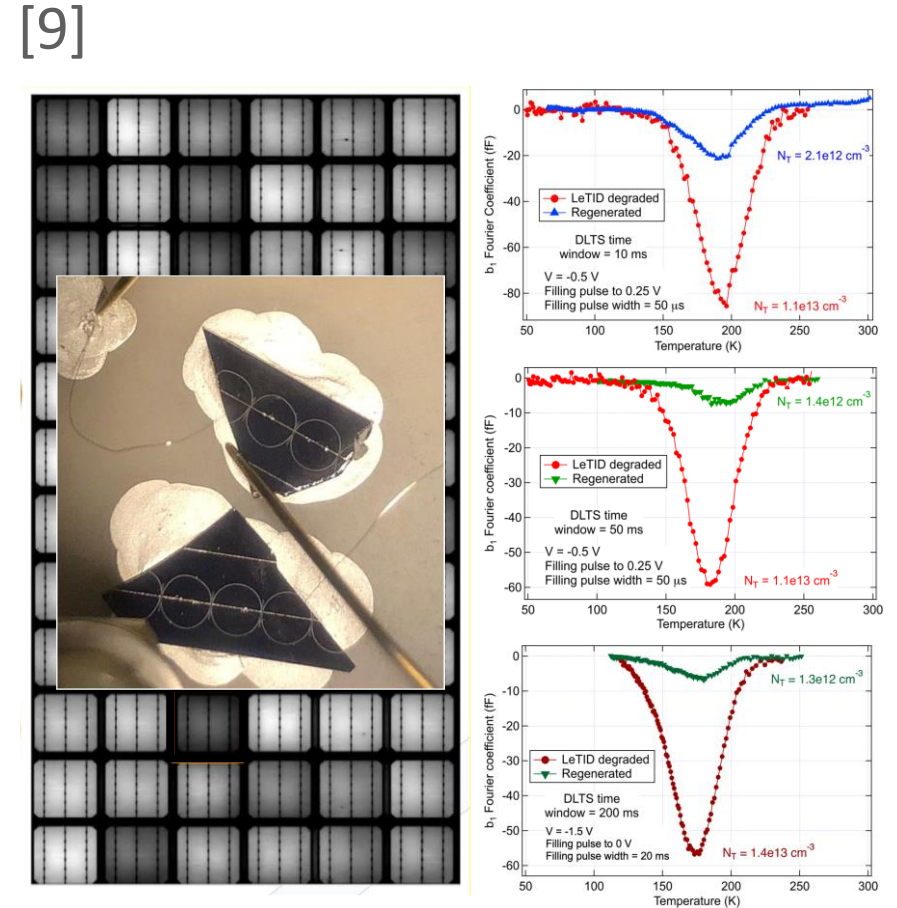
Light and elevated Temperature Induced Degradation (LeTID)

- Is LeTID still a problem for the PV industry? - Almost not^[4,5].
- Has the role of hydrogen in LeTID been proven? - Almost yes^[4].
- Do other defects/impurities, or layers play a role? - Maybe^[5].
- Can dopant-hydrogen complexes be a cause of LetiD? - Maybe^[6, 7].
- Is the LeTID mechanism understood? - Not^[4,5,7].

[4] D. Chen, et al., **2021**
[5] L. Ning, et al., **2022**
[6] T.O. Abdul Fattah, et al., **2023**
[7] J. Coutinho, et al., **2024**



[8] T. Mchedlidze, et al., 2019

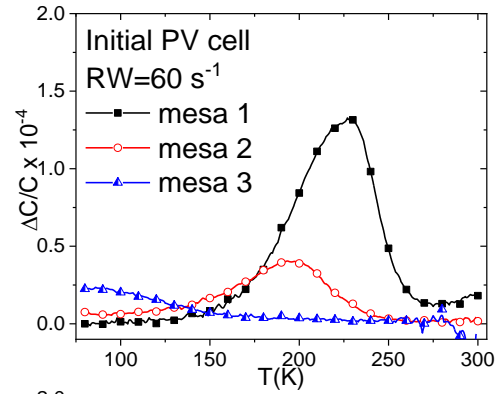


[9] S. Johnston, et al., 2022

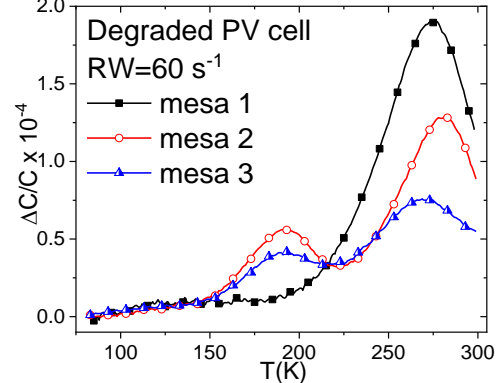
Experiments with “multisamples”

DLTS: similar locations cutout from „sister“ wafers of PV-cell in:

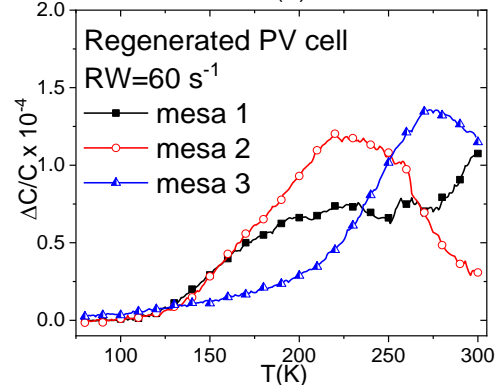
Initial state:



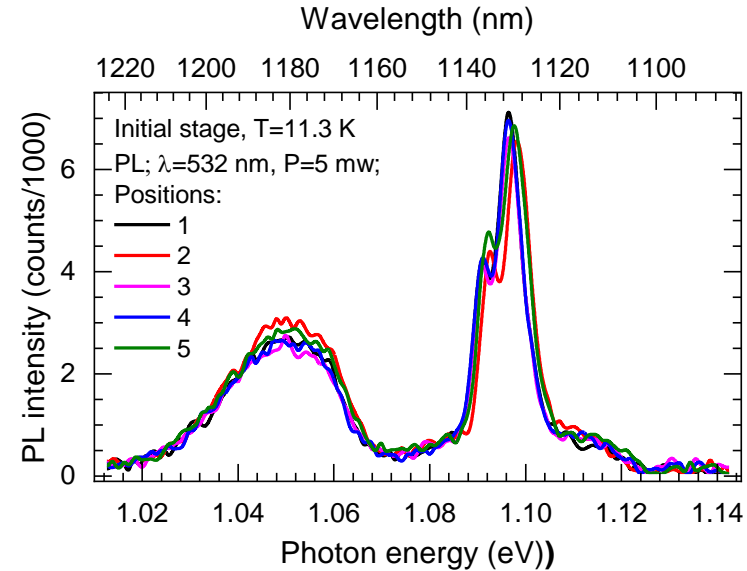
Degraded state:



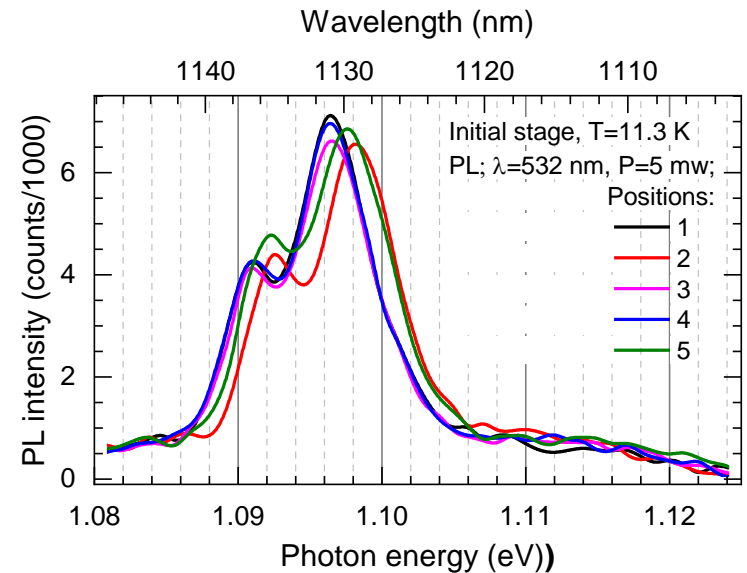
Regenerated state:



PL: different locations on the same PV-cell in **initial state:**



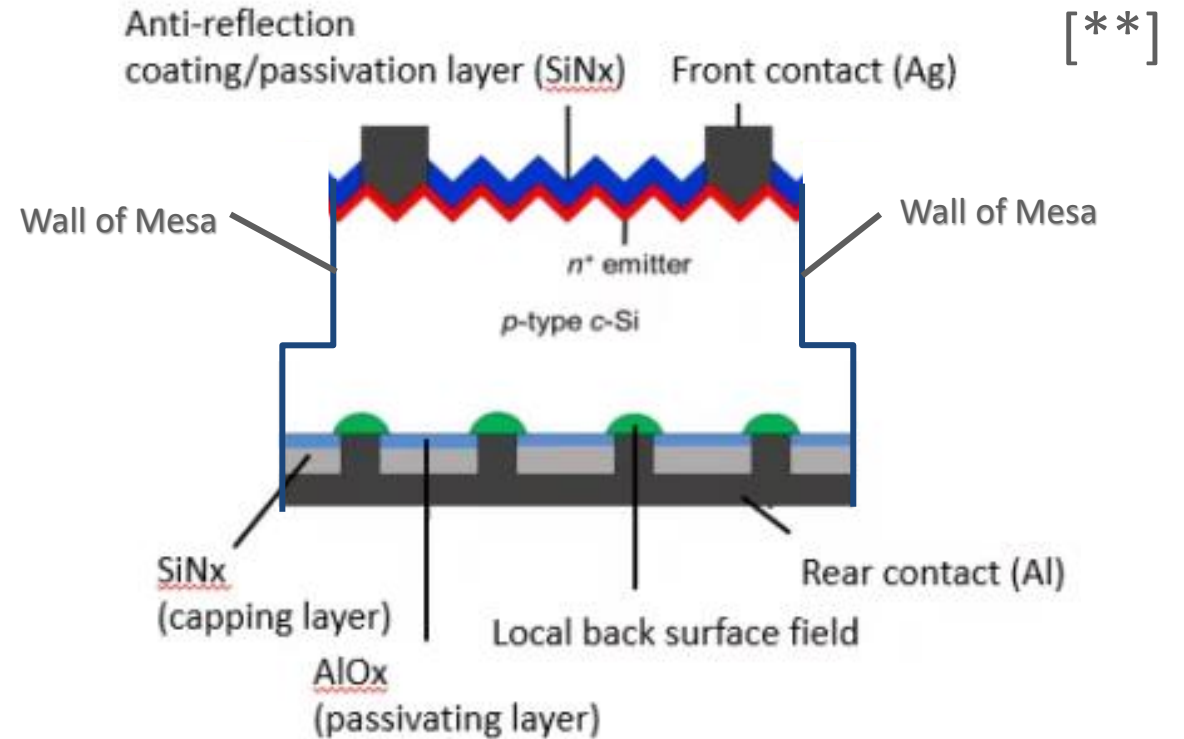
Near BG spectra



Details near BE, FE

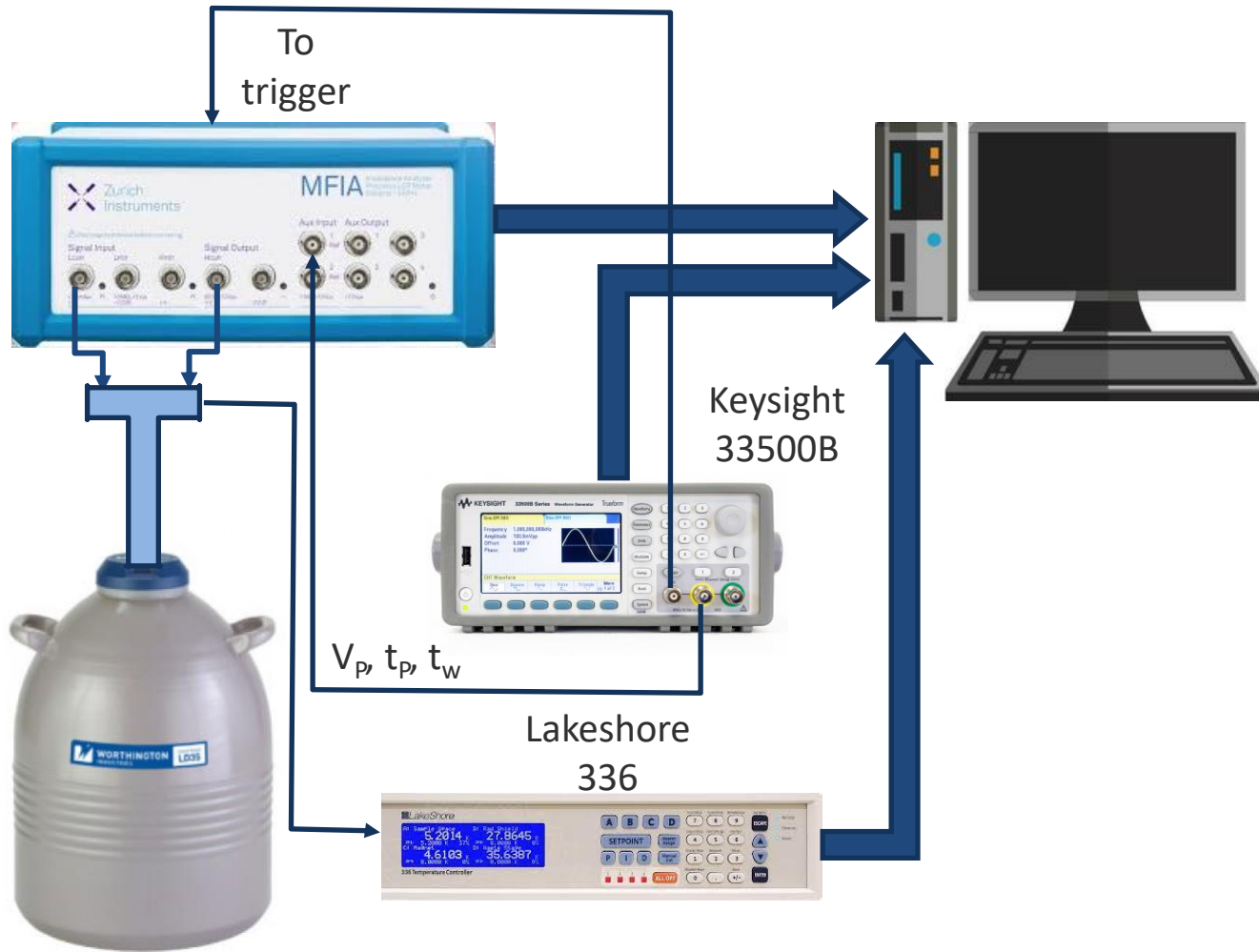
Mesa samples from solar cells^[*]

- PERC solar cells, Cz-Si, standard PERC fabrication procedure [2], B-doped, $N_B = 1.1 \cdot 10^{16} \text{ cm}^{-3}$;
- Mesa-diodes prepared from the PERC cells using chemical etching process;
- Three LeTID states: initial (I), degraded (D), regenerated (R);
- “Multisamples”: mesa diodes on samples cutout from similar locations of sister wafers for I, D, and R states; D and R were processed on complete solar cells by CID procedure;
- “Monosample”: the same sample (mesa diode) for I, D, and R stages obtained by on-stage CVID procedure, degradation (50 min) and regeneration (6 h).



[*] Samples were fabricated in the frame of the “ZORRO” project (contract no. 03EE1051D).

[**] <https://hjtpv.com/perc-technology-and-solar-panels/>



Sample

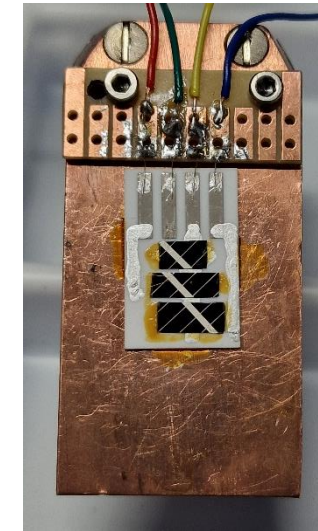
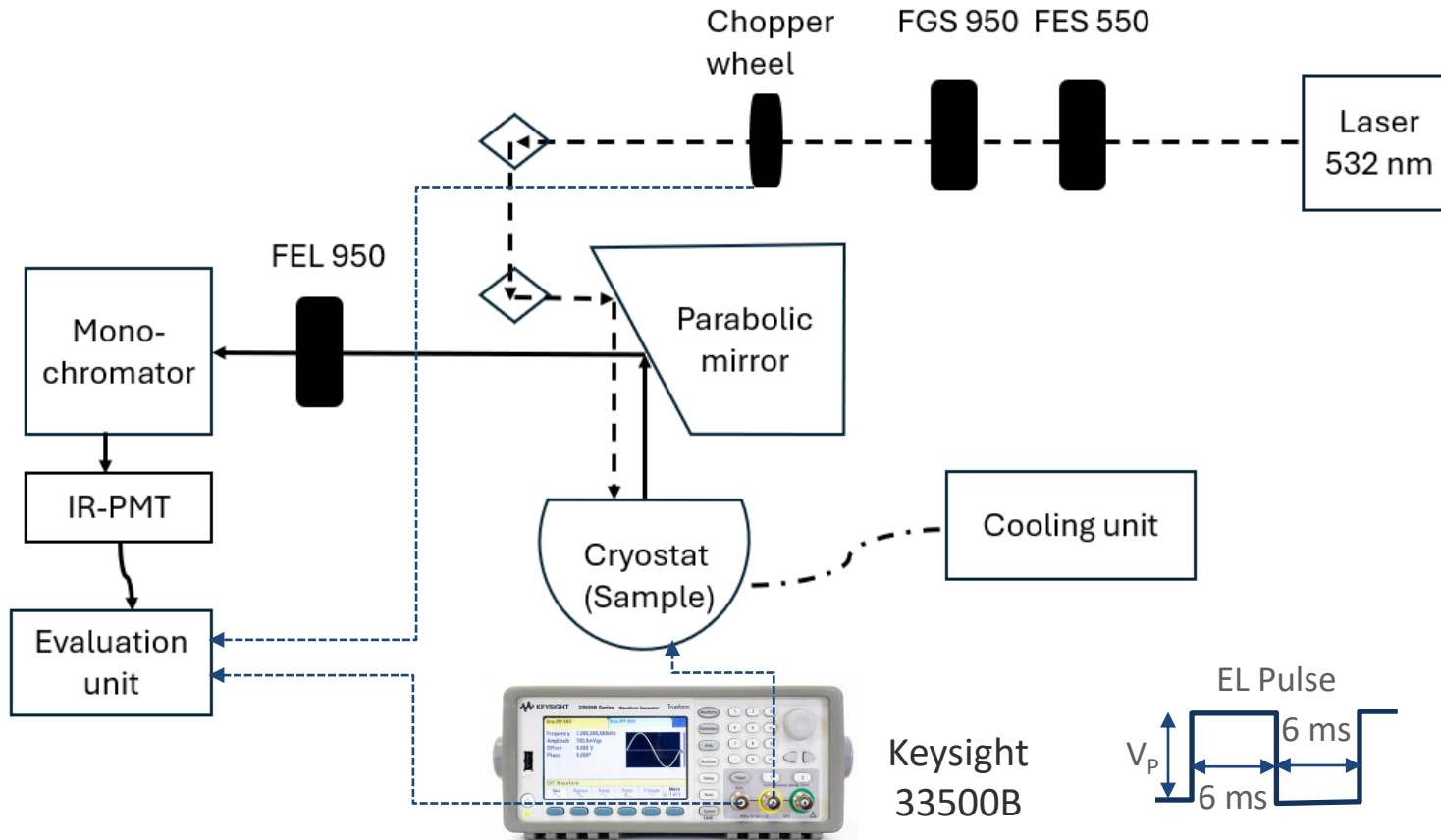


Thermalsensor



[10] T. Mchedlidze, 2023

EL(.....) and PL(- - - -) setup



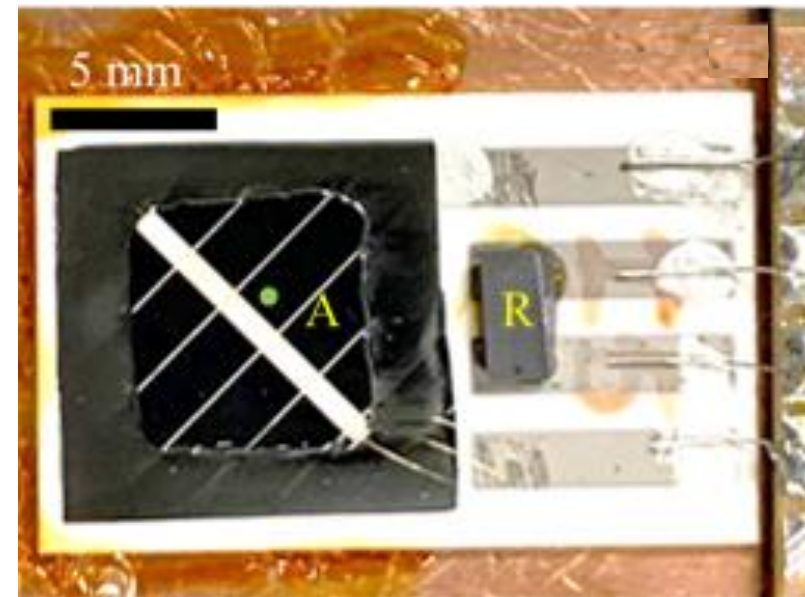
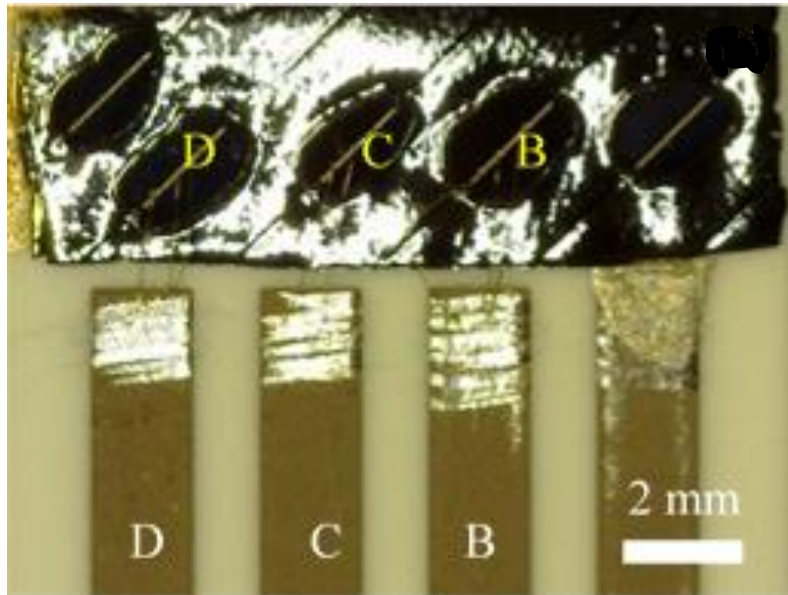
On-stage LeTID of mesa-diodes

Can local methods for defect investigation be applied for LeTID investigations in the cells and, if “yes”, how?

Study of the same samples mounted on the measuring setup in initial, degraded and regenerated states.

For DLTS

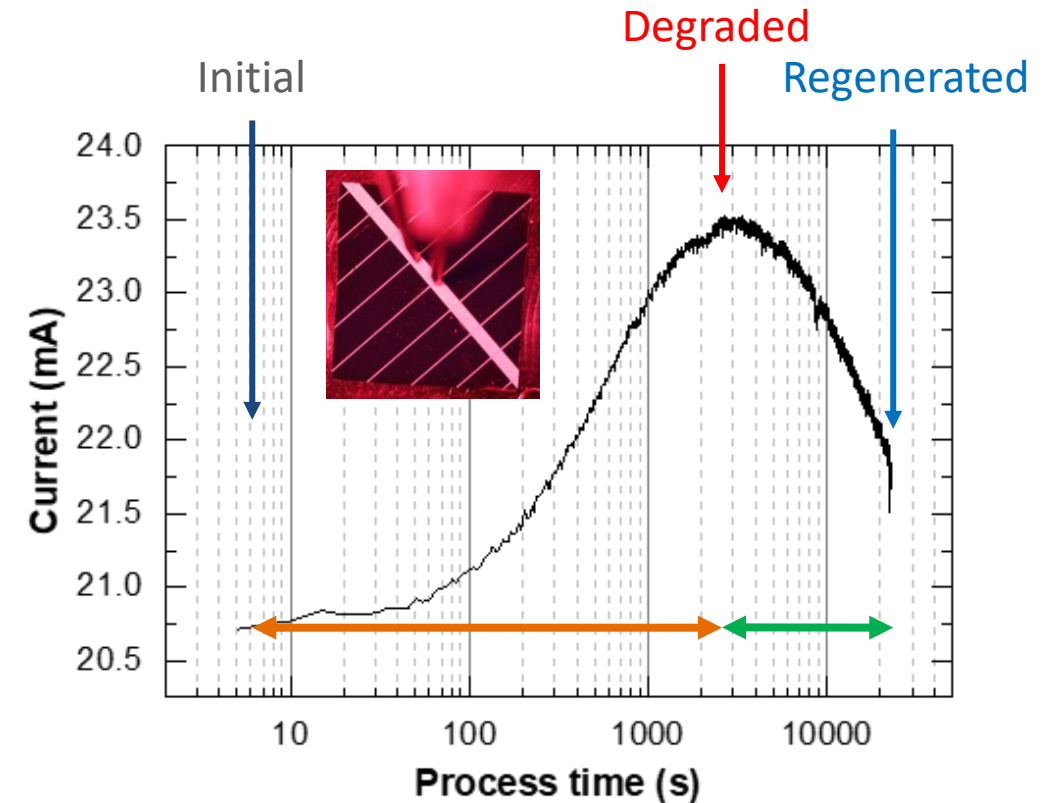
For LT-EL-PL



On-stage LeTID of mesa-diodes:

Degradation procedure

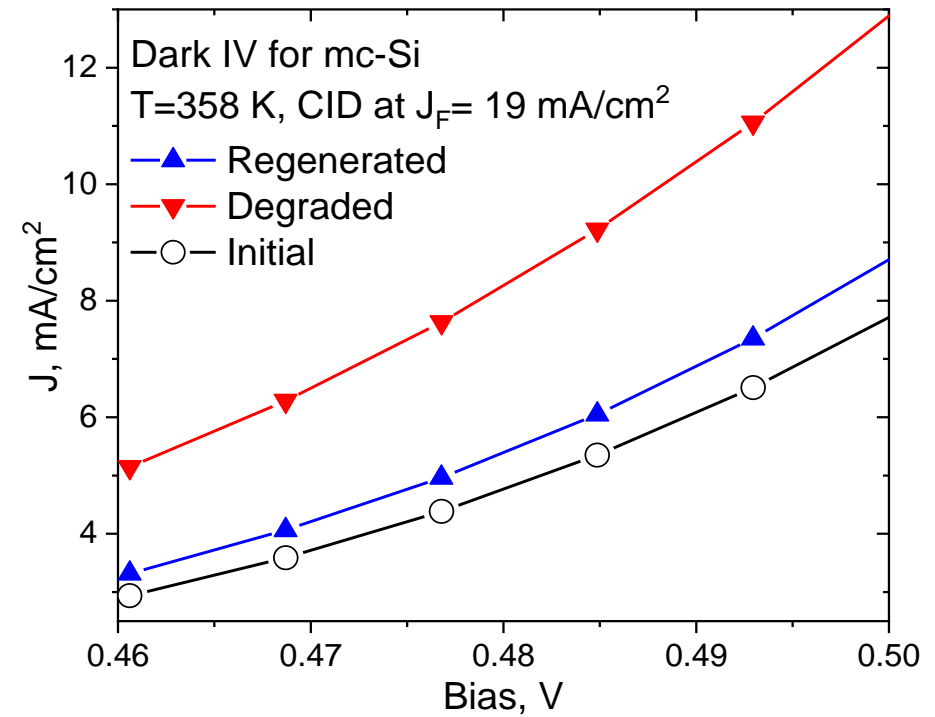
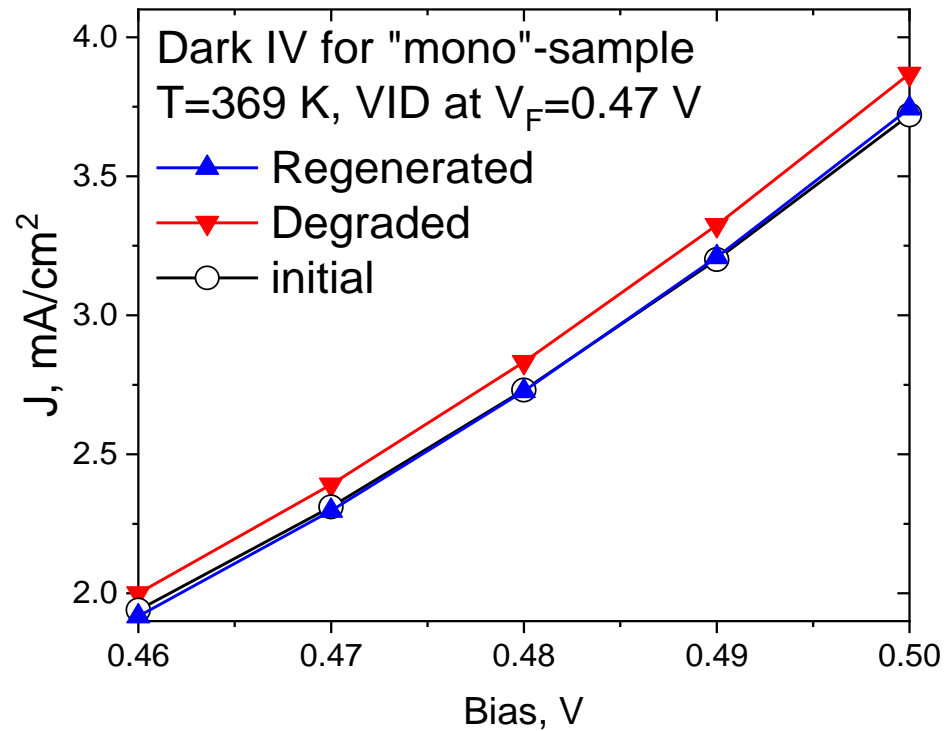
- Current induced degradation (CID) at elevated temperatures is frequently used to model LeTID^[4].
- However, due to leakage current at the perimeter of mesa diodes, especially for small area mesas, it is preferable to use constant voltage induced degradation (CVID).
- CID \approx CVID was confirmed.
- From the experimental LeTID curve:
 - $t(\text{degradation}) = 50 \text{ min}$;
 - $t(\text{regeneration}) = +6 \text{ hours}$.



Area of cleaved out cell 1 cm^2
 $V_{F, \text{const}} = 470 \text{ mV}$, $T = 369 \text{ K}$

[4] D. Chen, et al., 2021

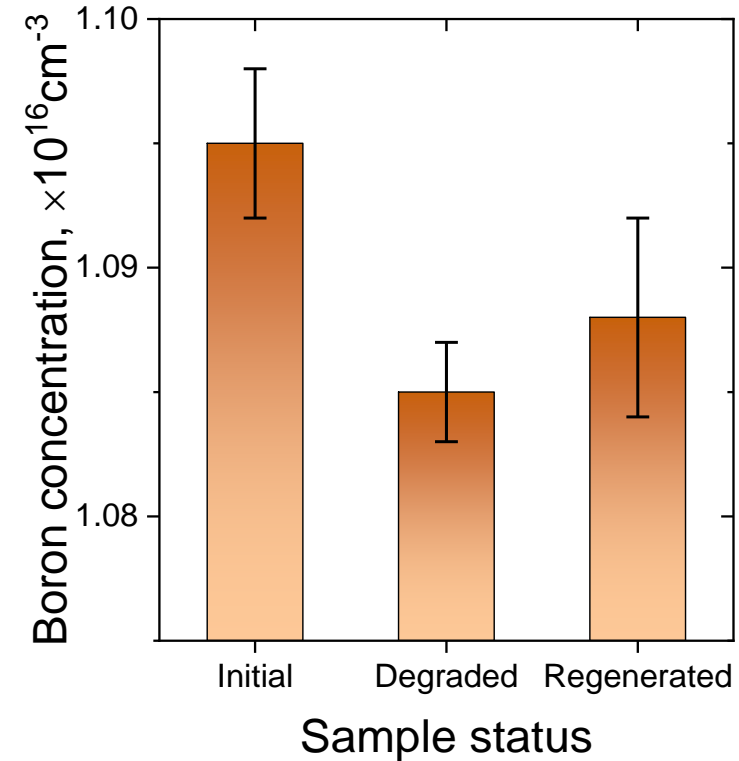
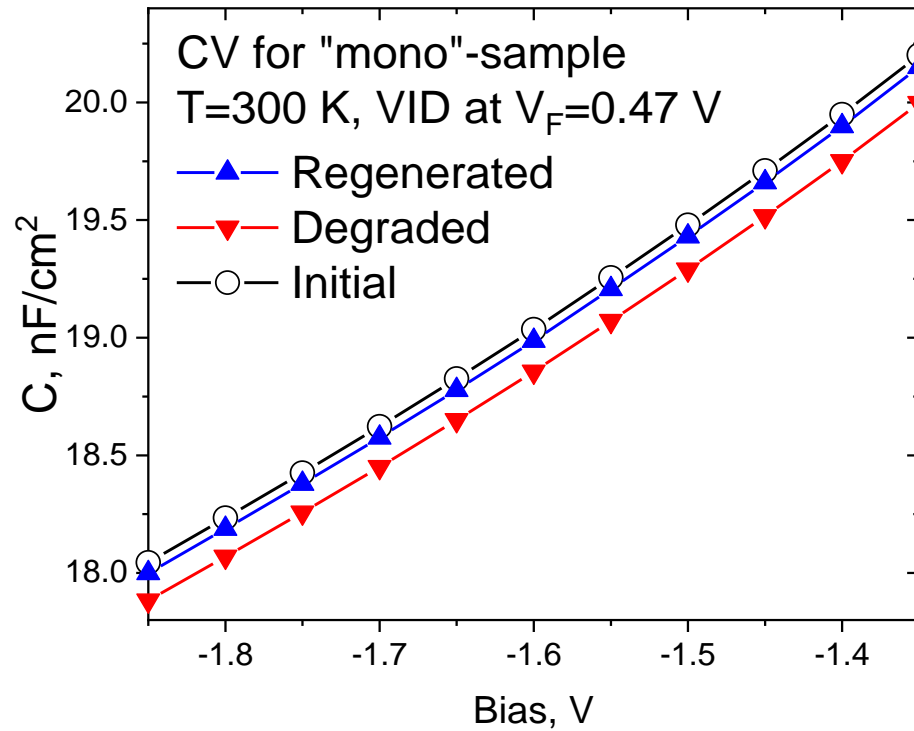
On-stage LeTID of mesa-diodes: dark IV



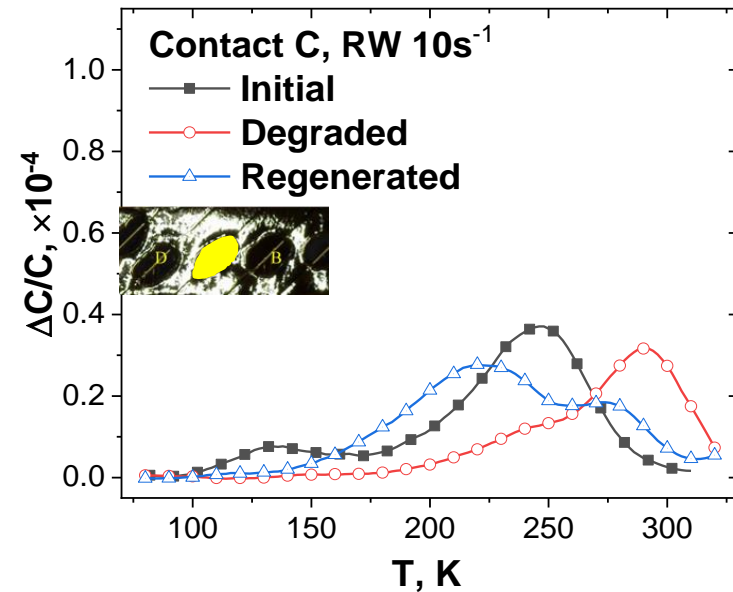
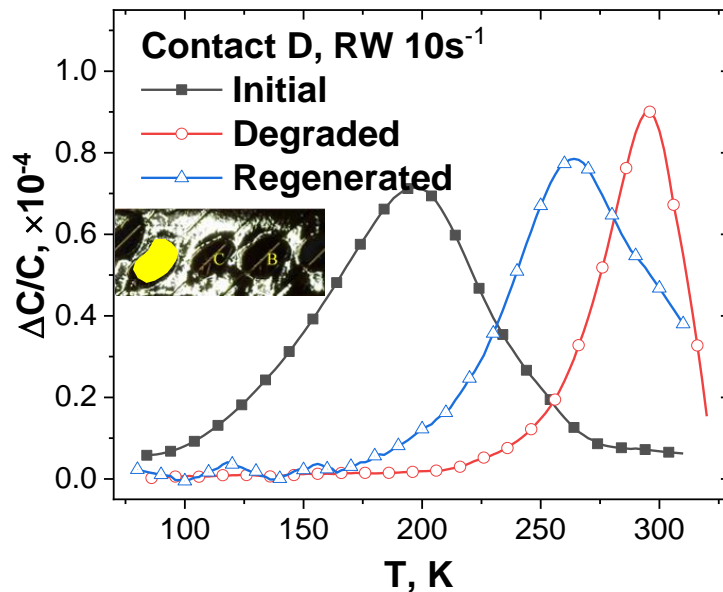
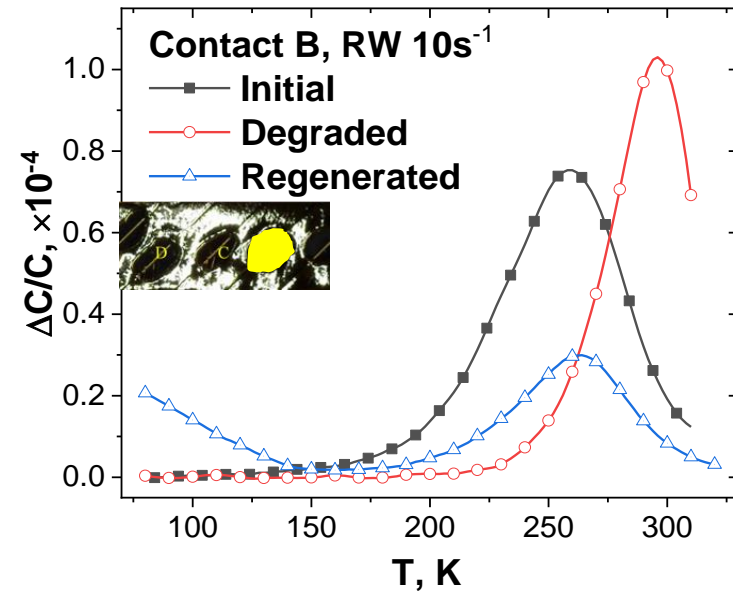
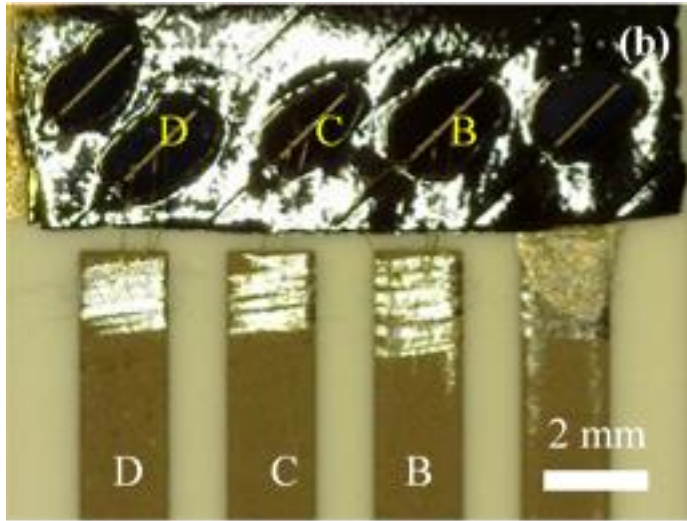
Similarities between CVID on mesa diode and CID on complete mc-Si solar cell.

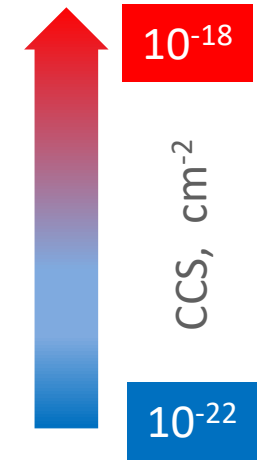
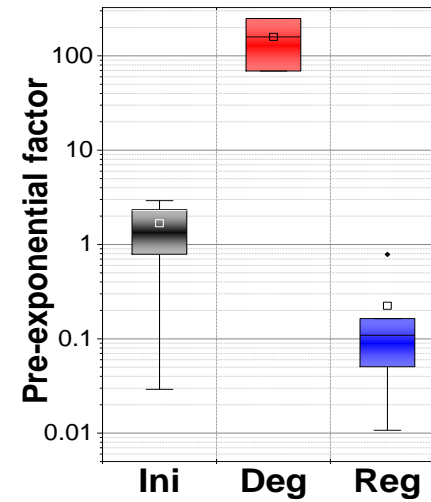
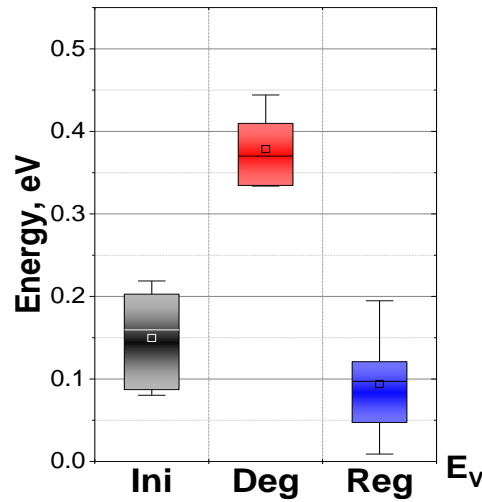
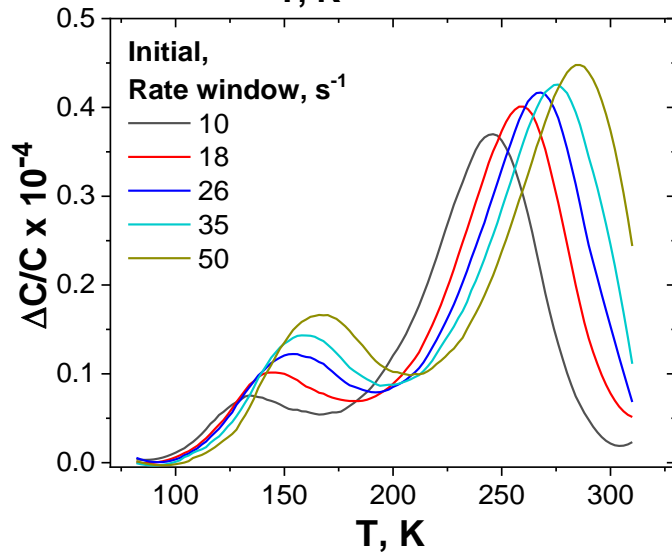
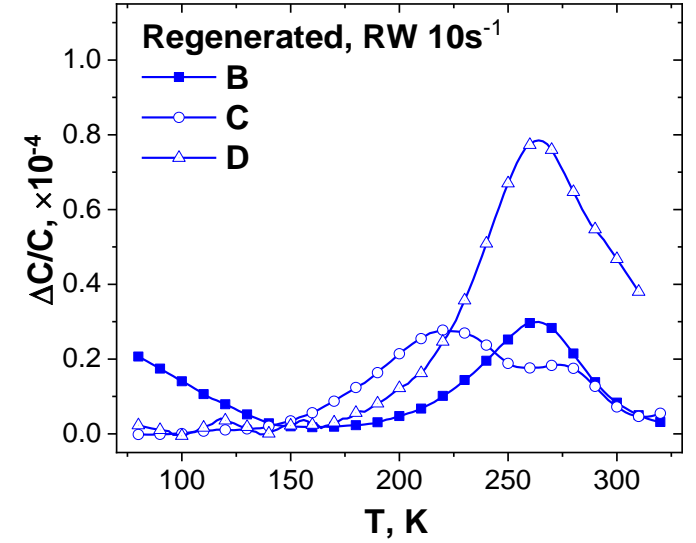
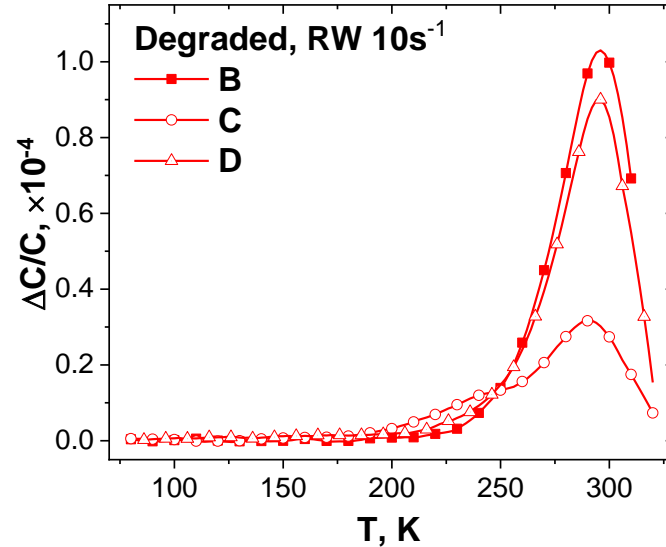
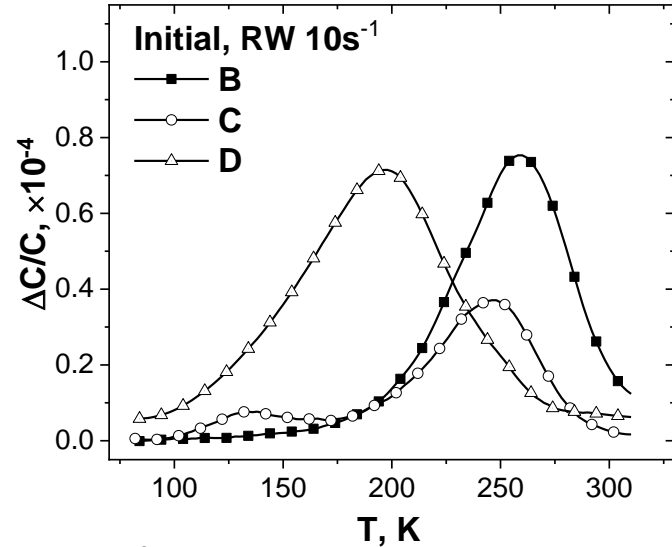
On-stage LeTID of mesa-diodes:

CV measurements

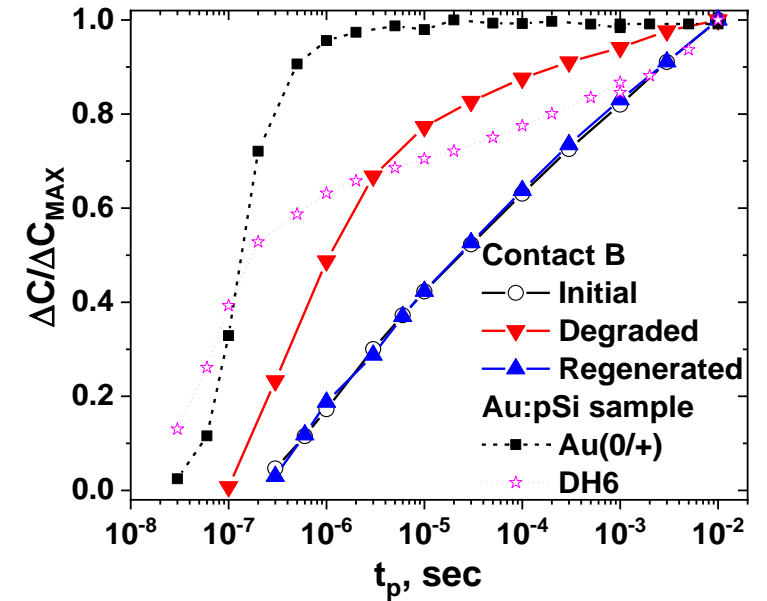
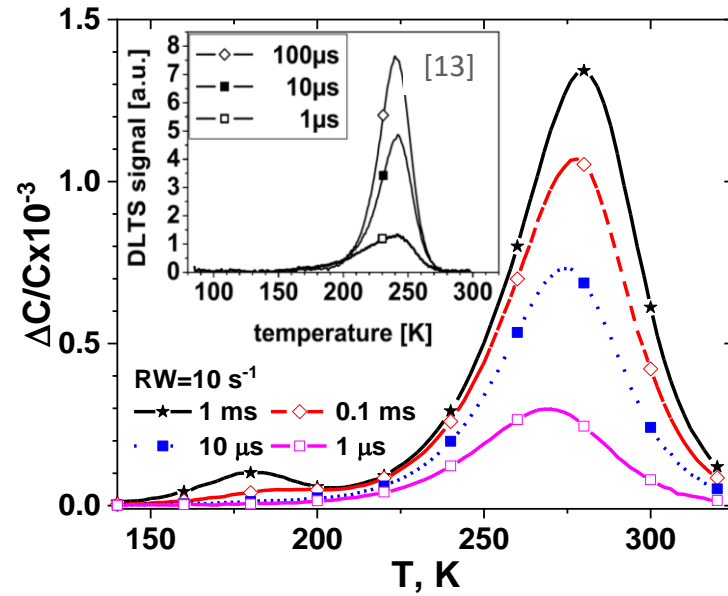
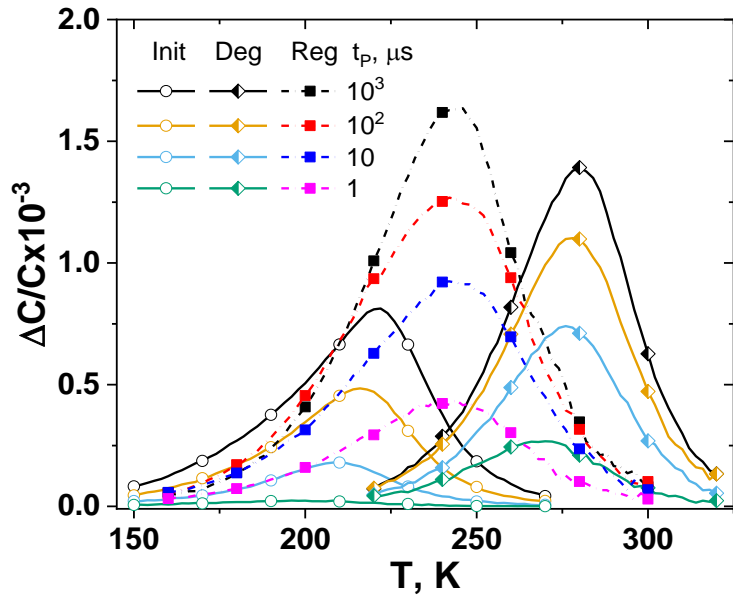


Changes in CV curves indicate on suppression of dopants in degraded state.





[11] M. K. Juhl, et al., 2023
 [12] J. T. Ryan, et al., 2015

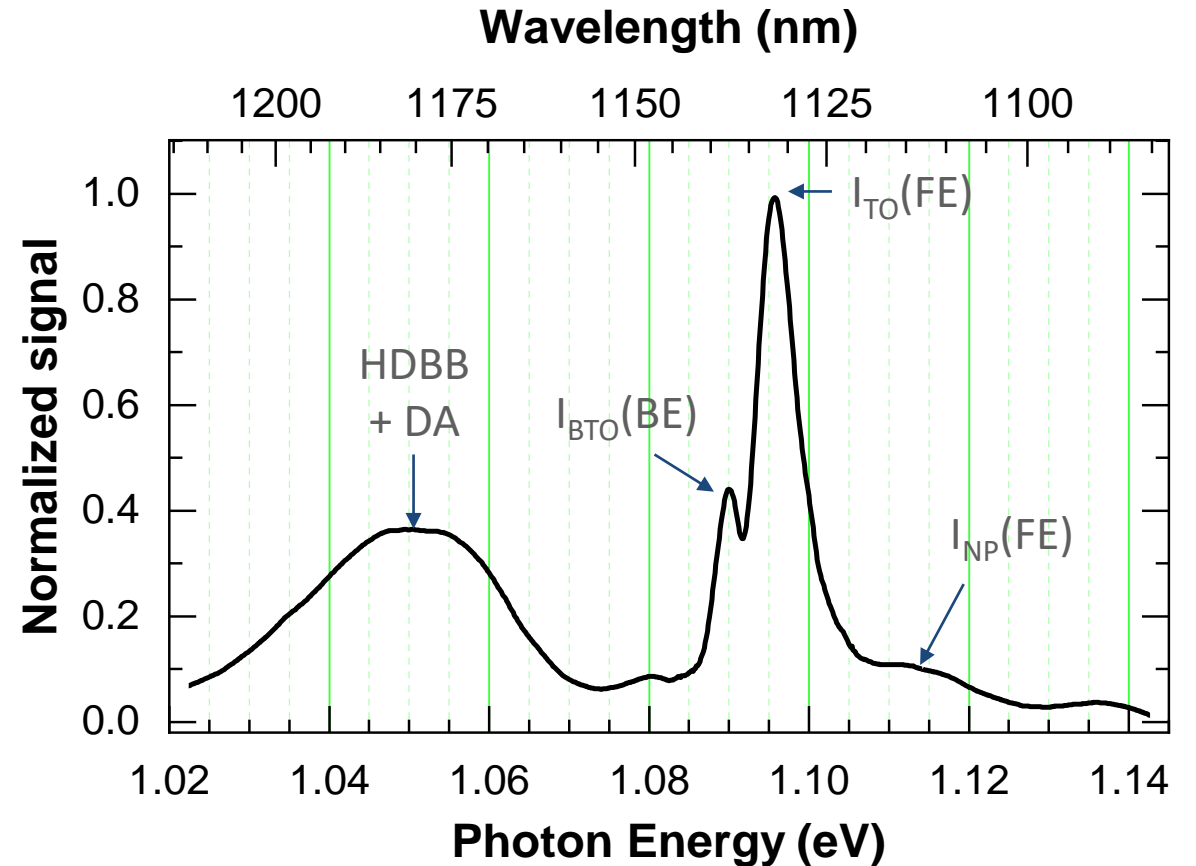
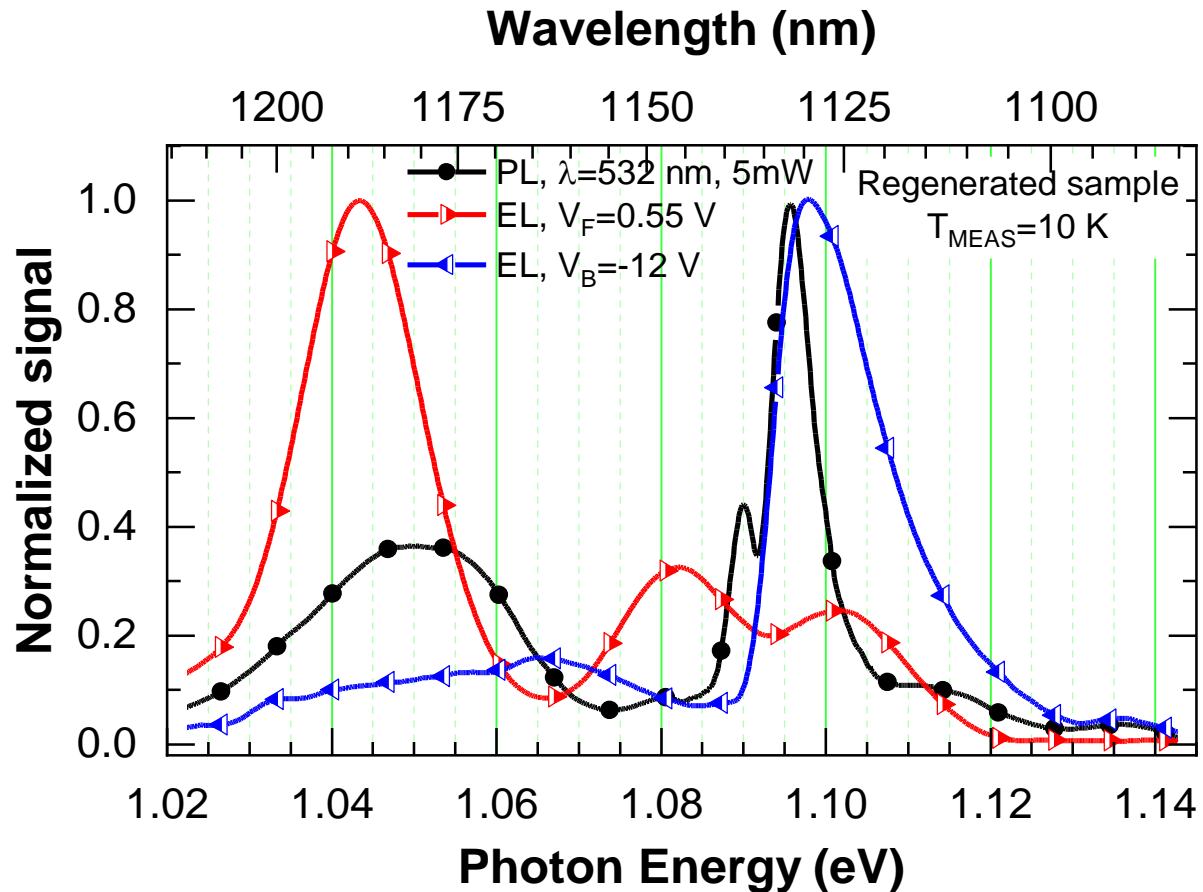


- Exact nature of the detected extended defects is not clear, however dislocations [14, 15] should be considered as candidates.
- Due to substantial leakage and overlap with majority carrier trap peaks we did not succeed detecting minority carriers in mesa diodes.

[13] M. Seibt, et al., 2009
 [14] L. Wang, et al., 2023
 [15] H.T. Nguen, et al., 2016

On-stage LeTID of mesa-diodes: luminescence

PL, $\lambda_{\text{EXC}}=532 \text{ nm}$, $P_{\text{EXC}}=5 \text{ mW}$, $T_{\text{MEAS}}=10 \text{ K}$



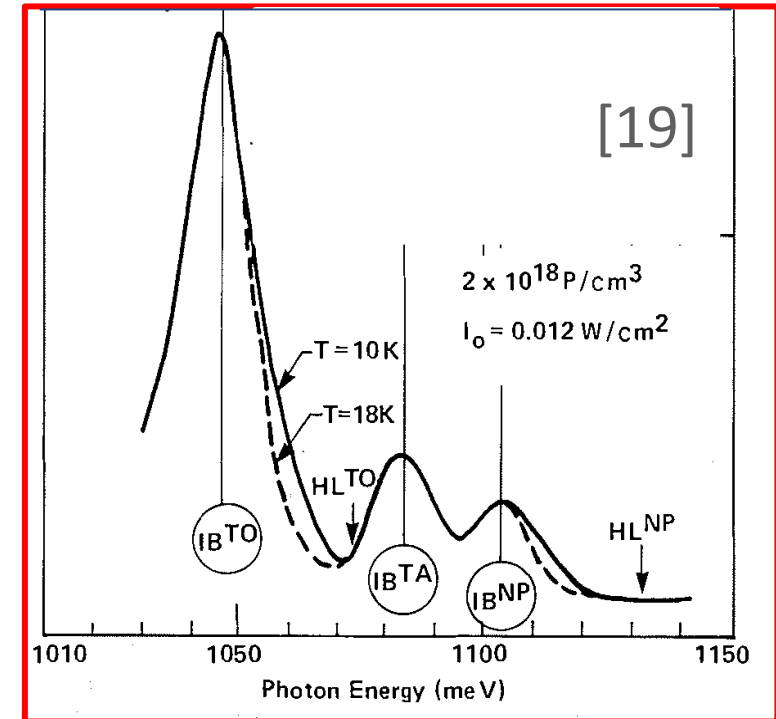
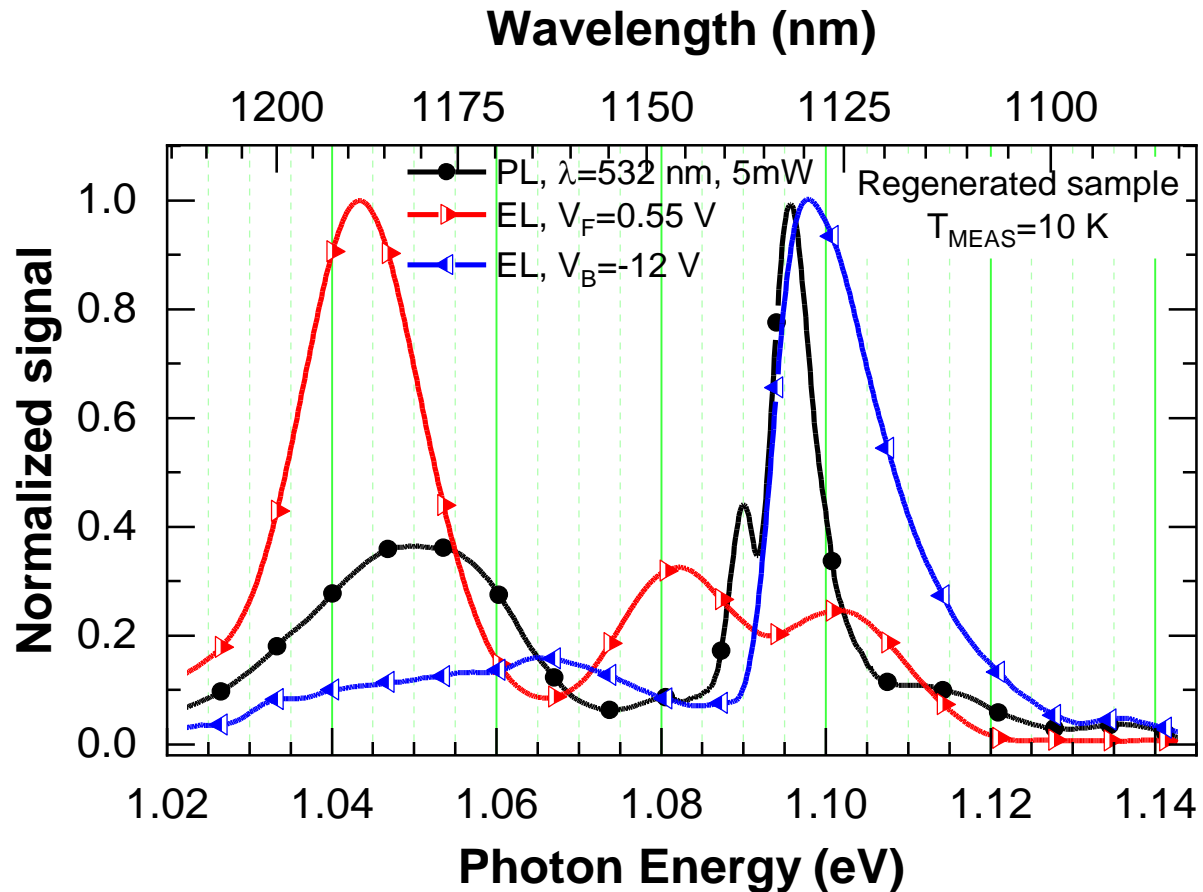
[16] M. Tajima, et al., 2011

[17] H.T. Wu, et al., 2018

[18] K. Peh, et al., 2023

On-stage LeTID of mesa-diodes: luminescence

EL, Forward bias, $V_{PULSE}=0.55\text{ V}$, $T_{MEAS}=10\text{ K}$



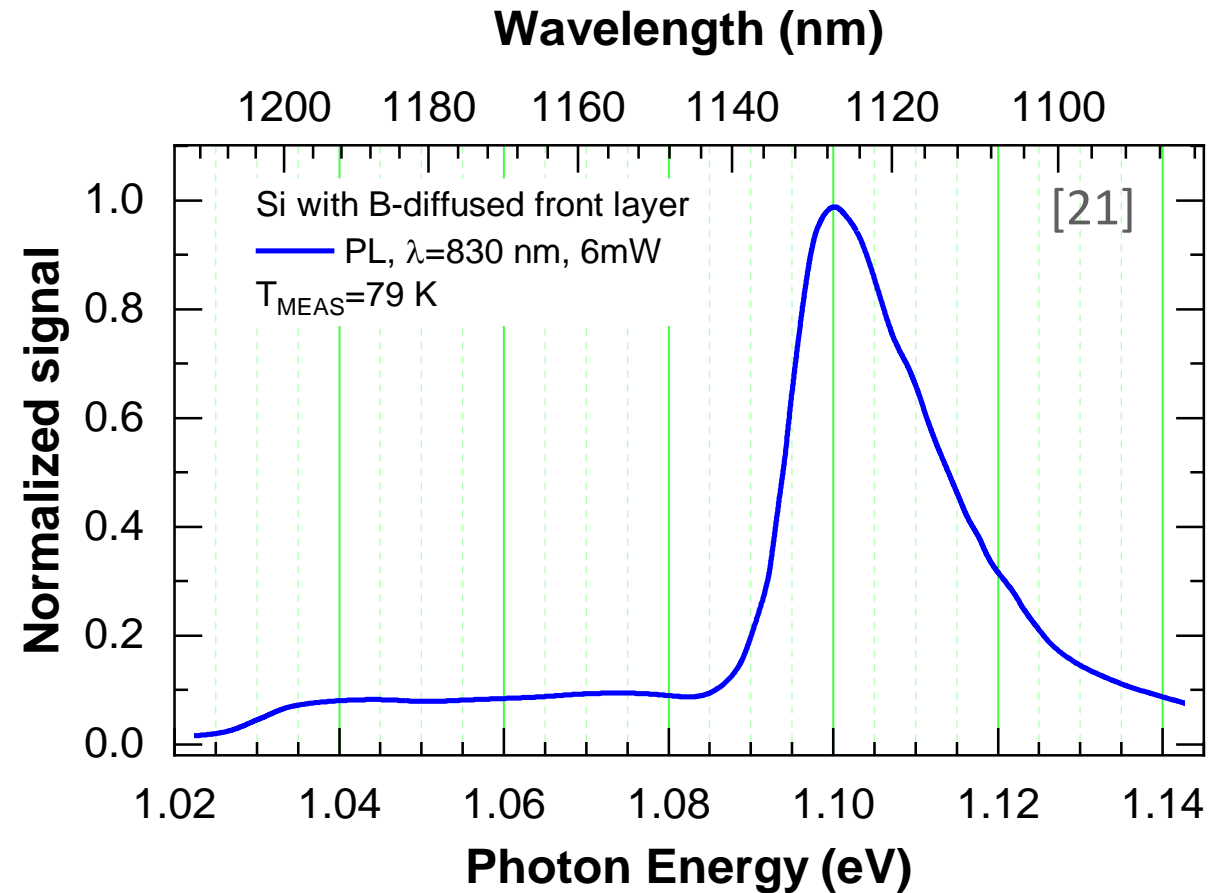
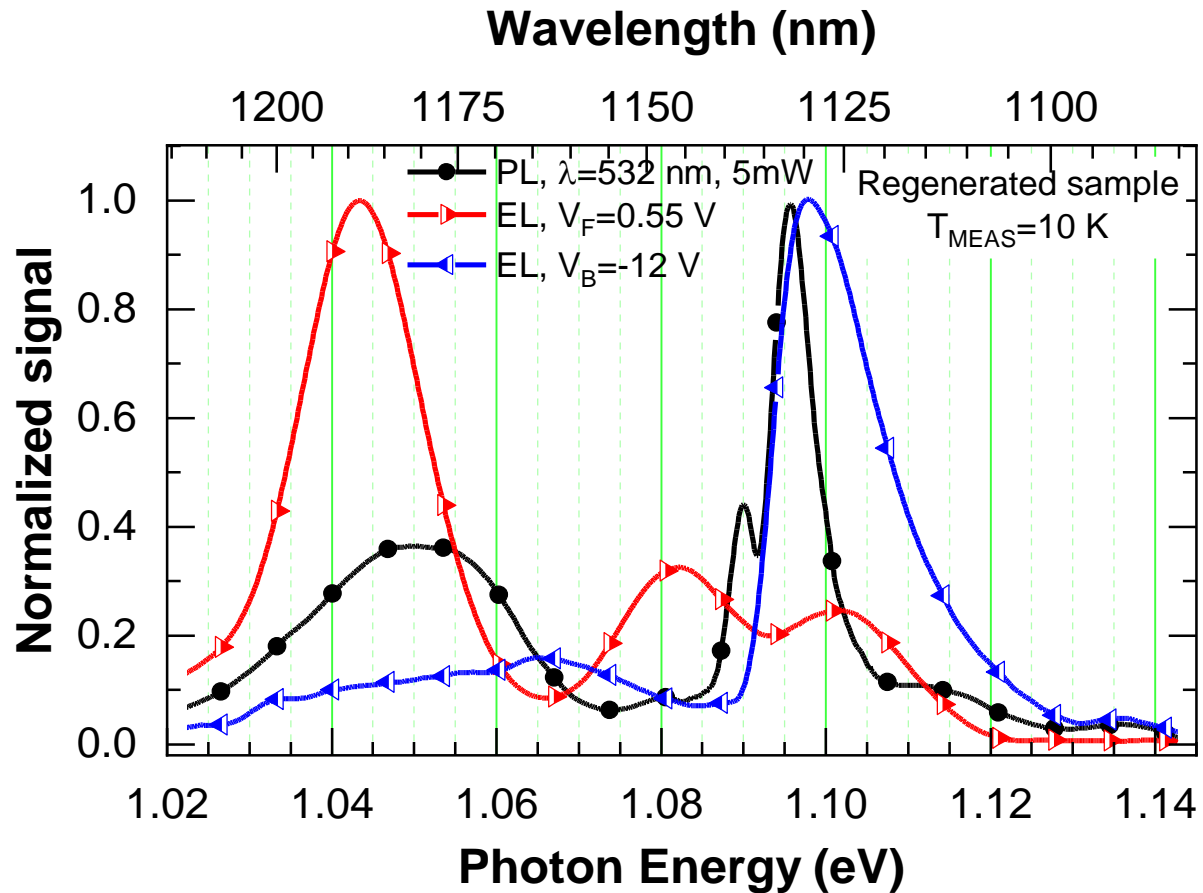
[19] R.R. Parsons, 1978

[20] J. Wagner, 1984

[16] M. Tajima, et al., 2011

On-stage LeTID of mesa-diodes: luminescence

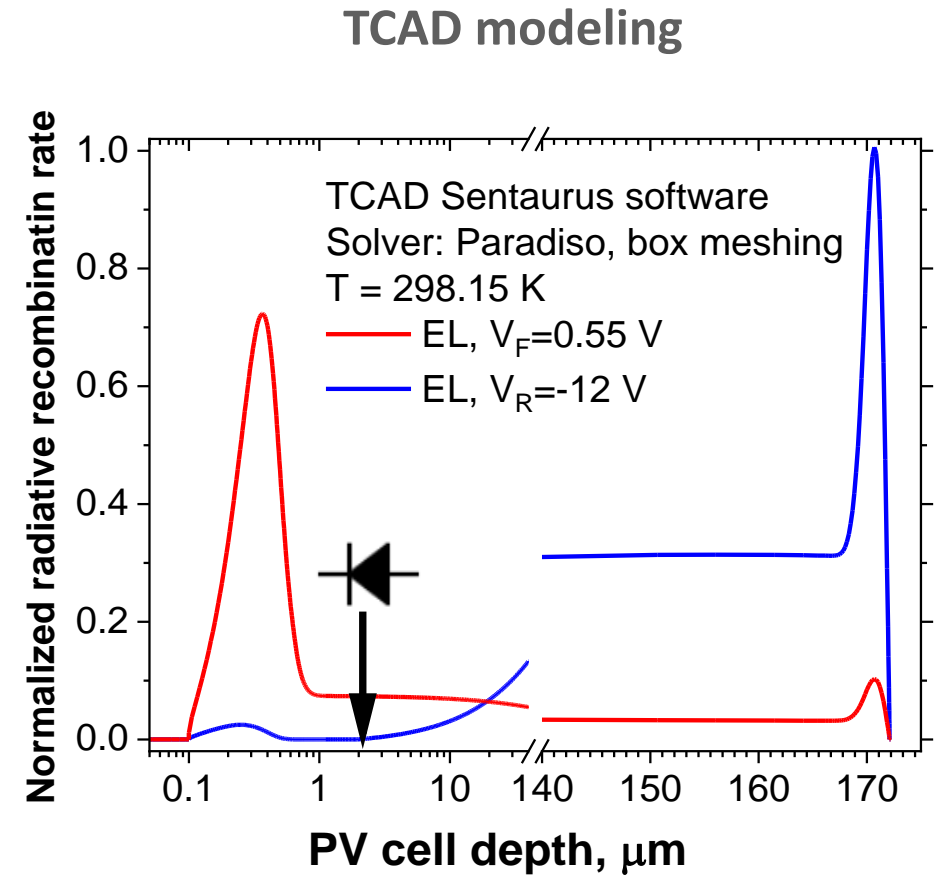
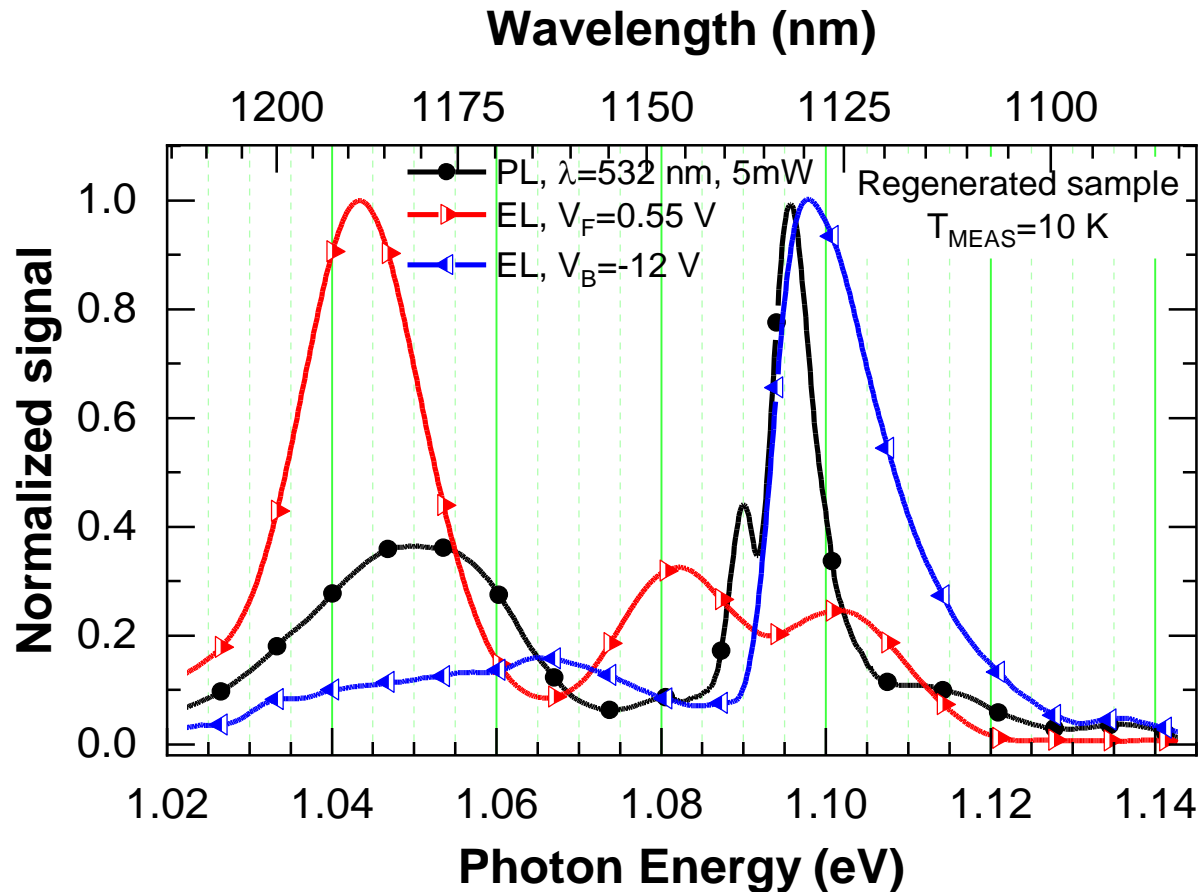
EL, Reverse bias, $V_{PULSE} = -12\text{ V}$, $T_{MEAS} = 10\text{ K}$



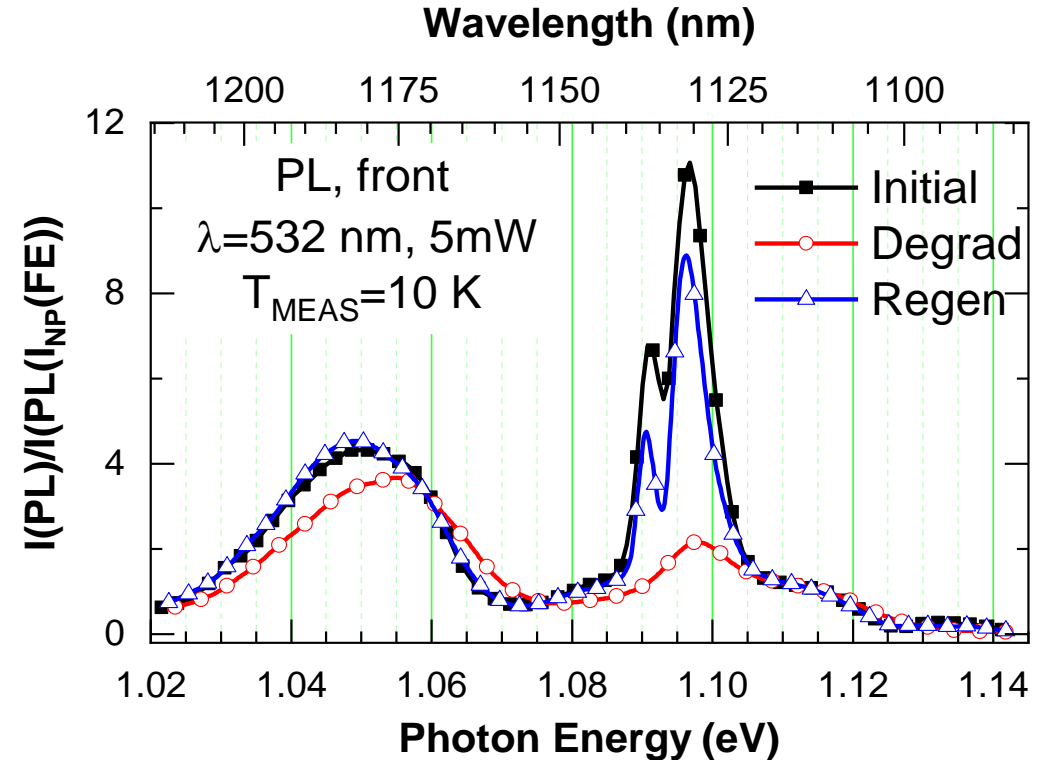
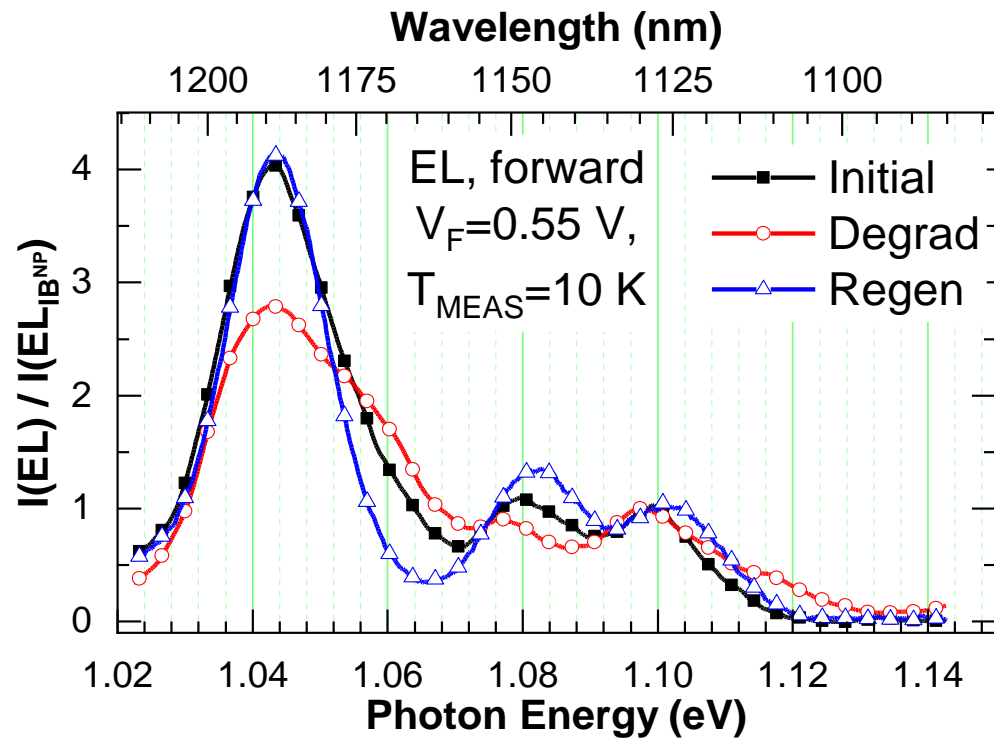
[21] H.T. Nguyen, et al., 2015

On-stage LeTID of mesa-diodes: luminescence

Electroluminescence, TCAD modeling



Results



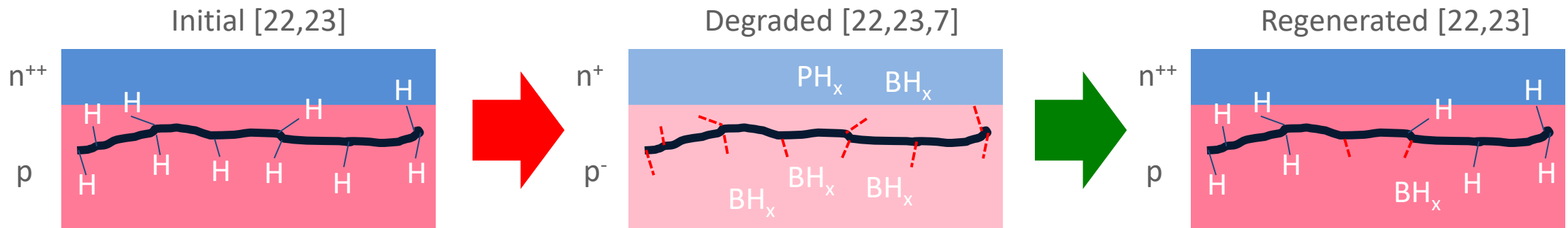
- Similar EL, PL spectra for the initial and regenerated samples. Decrease of overall intensity for the degraded sample.

- For the degraded sample:
 - Changes in recombination in emitter caused by B (and P?) passivation.
 - Decrease of BE intensity in the bulk.

Short summary of observations:

Method	Detected properties	Initial & Regenerated	Degraded	Probable reason
DLTS	Electrical activity of extended defects	Low	High	Hydrogen
CV	Concentration of active boron near to the junction	Higher	Lower	BH ₂
PL & EL	Overall intensity	Higher	Lower	Ext. defects
	Intensity of boron related peaks	High	Low	BH ₂

Possible (additional?) mechanism of LeTID:



[22] M. Matsubara, et al., 2010

[23] J. Pankove, 1991

[7] J. Coutinho, et al., 2024

New methods proposed/used for LeTID study:

- On-stage degradation and regeneration of mesa PV cells for PL, EL and DLTS study.
- Low temperature (10 K) EL study under forward and reverse bias.
- Enhanced detection/characterization of extended defects by DLTS using MFIA-DLTS setup.

New results:

- We observed significant and reversible changes in local luminescence and electrical properties of PV cell during on-stage LeTID process.
- The changes can be attributed to interaction between extended defects, dopants and hydrogen and can imply a mechanism (additional?) of LeTID.

Acknowledgments:

We would like to thank the partners from Fraunhofer IISB, ISC Konstanz and University of Konstanz for solar cell fabrication and characterization as well as BMWK for funding the “ZORRO” project (contract no. 03EE1051D).



Thanks are also due to Jan Bayer, Amy Albrecht, and Kuei-Shen Hsu (Bergakademie Freiberg) for their assistance with PL measurements and Steffi GÜldner for help with sample preparations.

- [1] K. Ramspeck, S. Zimmermann, H. Nagel, et al. Light induced degradation of rear passivated mc-Si solar cells, in: Proc. 27th Eur. Photovolt. Sol. Energy Conf., **2012**: pp. 861–865, DOI: 10.4229/27THEUPVSEC2012-2DO.3.4
- [2] F. Fertig, J. Broisch, D. Biro, S. Rein, Stability of the regeneration of the boron-oxygen complex in silicon solar cells during module certification. Sol Energy Mater sol Cells. **2014**;121: 157-162; DOI: 10.1016/j.solmat.2013.10.014
- [3] F. Kersten, P. Engelhart, H-C Ploigt, et al. Degradation of multicrystalline silicon solar cells and modules after illumination at elevated temperature. Sol Energy Mater sol Cells. **2015**; 142: 83; DOI: 10.1016/j.solmat.2015.06.015
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- [6] T.O. Abdul Fattah, V.P. Markevich, D. Gomes, J. Coutinho, N.V. Abrosimov, I.D. Hawkins, M.P. Halsall, and A.R. Peaker, "Interactions of hydrogen atoms with boron and gallium in silicon crystals co-doped with phosphorus and acceptors", Solar Energy Mat Solar Cells, **2023**, 259: 112447. DOI: 10.1016/j.solmat.2023.112447
- [7] J. Coutinho, D. Gomes, V.J.B. Torres, T.O. Abdul Fattah, V.P. Markevich, and A.R. Peaker, Hydrogen Reactions with Dopants and Impurities in Solar Silicon from First Principles; Sol. RRL **2024**, 8: 2300639, DOI: 10.1002/solr.202300639
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- [11] M.K. Juhl, F.D. Heinz, G. Coletti, F.E. Rougieux, C. Sun , M.V. Contreras, T. Niewelt, J. Krich, and M.C. Schubert, On the Conversion Between Recombination Rates and Electronic Defect Parameters in Semiconductors, IEEE J Photovolt, **2023**, 13: 524; DOI: 10.1109/JPHOTOV.2023.3267173

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- [15] H.T. Nguyen, S. Pheng Phang, and D. Macdonald, Evaluating depth distributions of dislocations in silicon wafers using micro-photoluminescence excitation spectroscopy, *Energy Procedia*, **2016**; 92: 145; DOI: 10.1016/j.egypro.2016.07.013
- [16] M. Tajima, T. Iwai, H. Toyota, S. Binetti, And D. Macdonald, Donor–acceptor pair luminescence in compensated Si for solar cells, *J Appl Phys*, **2011**; 110: 043506; DOI: 10.1063/1.3622560
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- [18] K. Peh, A. Flötotto, K. Lauer, D. Schulze, D. Bratek, and S. Krischok, Calibration of Low-Temperature Photoluminescence of Boron-Doped Silicon with Increased Temperature Precision, *Phys Stst Sol B*, **2023**; 260: 23000300; DOI: 10.1002/pssb.202300300
- [19] R.R. Parsons, Photoluminescence in heavily-doped Si(P), *Can J Phys*, **1978**; 56: 814; DOI: 10.1139/p78-109
- [20] J. Wagner, Photoluminescence and excitation spectroscopy in heavily doped n- and p-type silicon, *Phys Rev B*, **1984**; 29: 2002; DOI: 10.1103/PhysRevB.29.2002
- [21] H.T. Nguyen, Di Yan, Fan Wang, P. Zheng, Y. Han, and D. Macdonald, Micro-photoluminescence spectroscopy on heavily-doped layers of silicon solar cells, *Phys. Status Solidi RRL*, **2015**; 9: 230; DOI: 10.1002/pssr.201510049
- [22] M. Matsubara, J. Godet, and L. Pizzagalli, Investigation of the interaction between hydrogen and screw dislocation in silicon by first-principles calculations, *J. Phys.: Condens. Matter*, **2010**; 22: 035803; DOI: 10.1088/0953-8984/22/3/035803
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Appendix 1: TCAD modelling

Software	TCAD Sentaurus O-2018.06-SP2
Materials	Silicon, Oxides and Aluminum
Domain	Smallest symmetrical element
Meshing	<ul style="list-style-type: none"> • “Box” method volume [μm^2] \rightarrow PERC: $1.192 \cdot 10^5$ MESA: $1.193 \cdot 10^5$ • Total number of elements \rightarrow PERC: 46,399 MESA: 71,986
Generation & V-range	$1.5 \cdot 10^{19} \left[\frac{1}{\text{cm}^3 \cdot \text{s}} \right]$ & $V [\text{mV}] \in [0; 690]$
Surface recombination	On all intermediate areas, not on edge surfaces
Physical models	<ul style="list-style-type: none"> • Intrinsic carrier density model: Schenk bandgap narrowing model and calculation by Altermatt et al. [2;3] • Charge carrier density mobility: Klaassen model [4;5]
Solver	Pardiso: Gaussian elimination for systems of equations

Appendix 1: TCAD modelling

Excess Charge carrier density

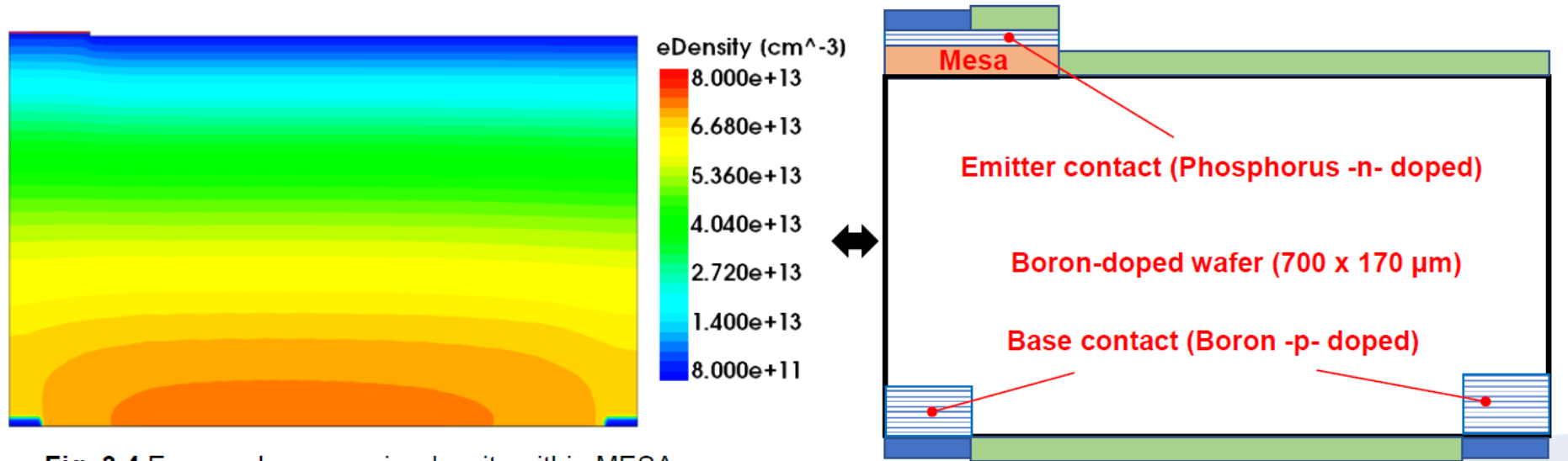
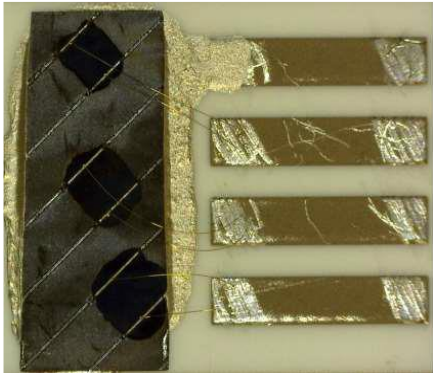


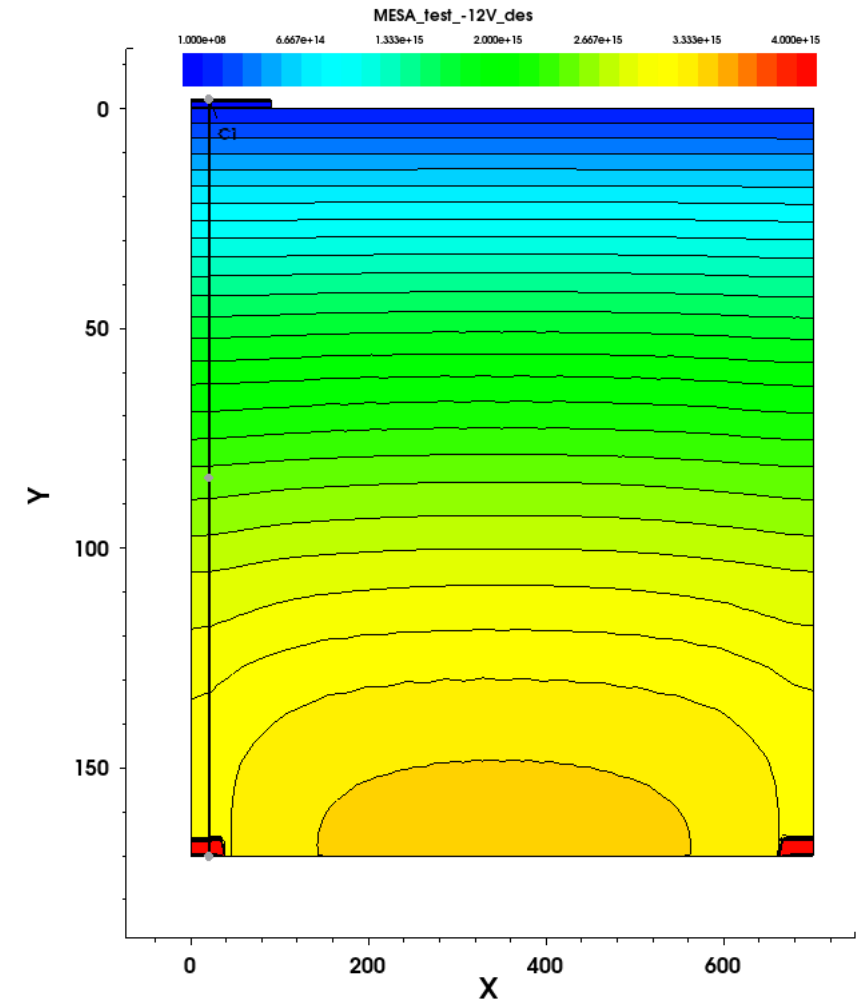
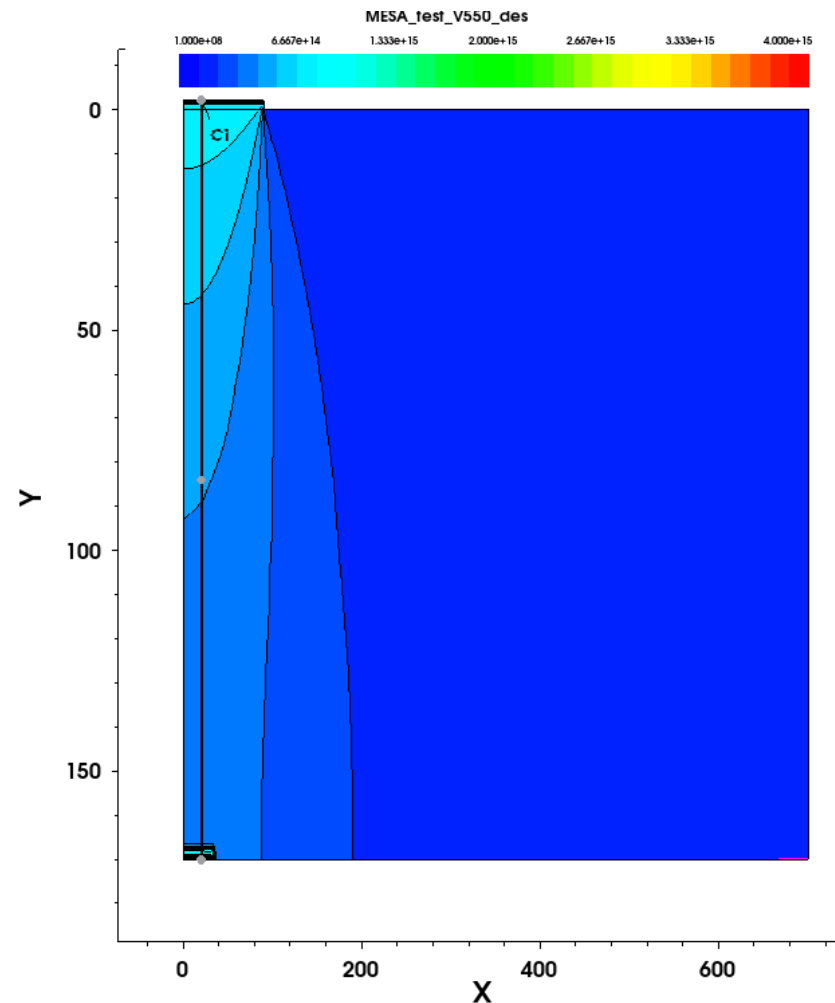
Fig. 3.4 Excess charge carrier density within MESA cell for $S_p = 2580 \left[\frac{cm}{s} \right]$ and $V_{MPP} = 488 [mV]$

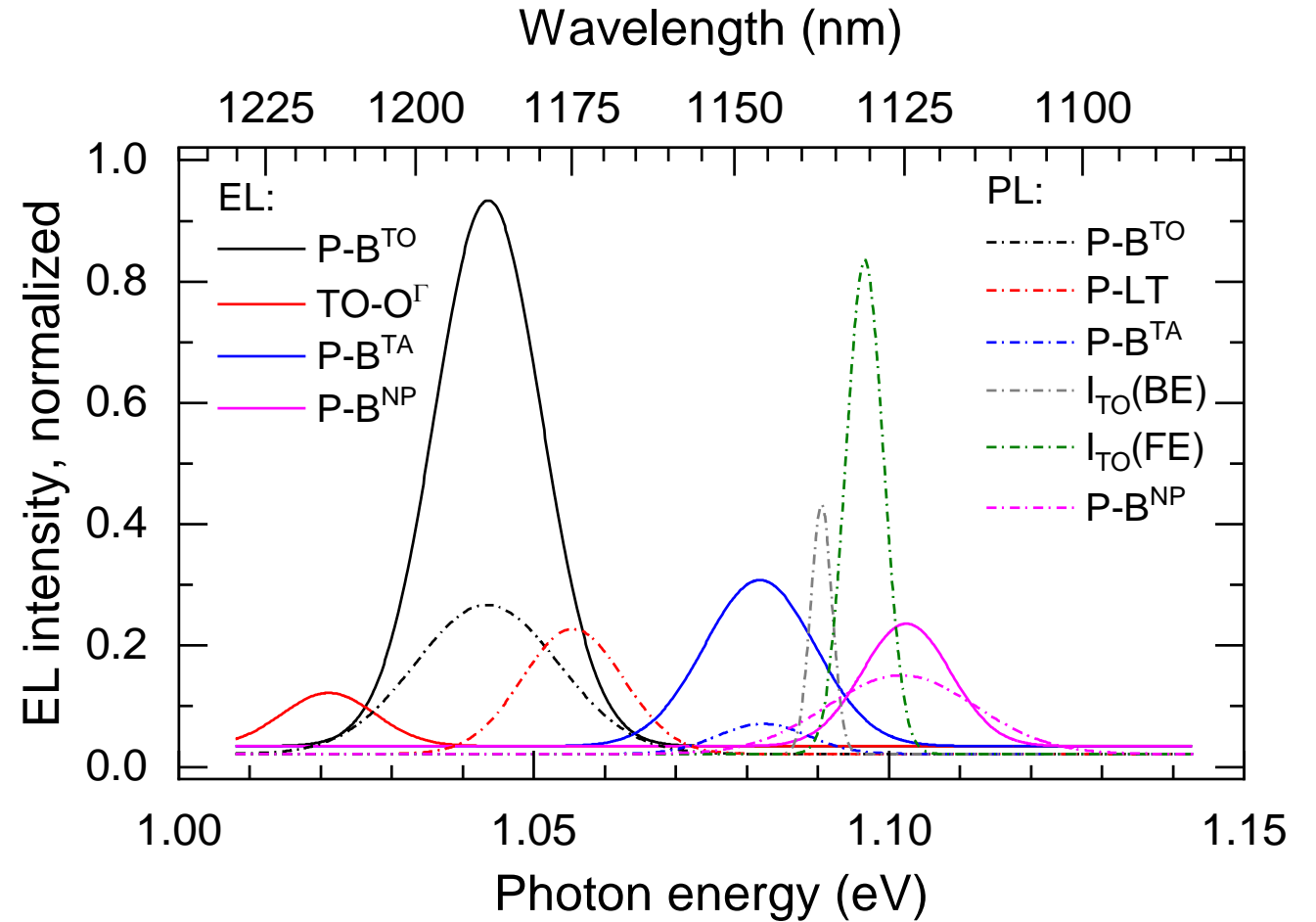
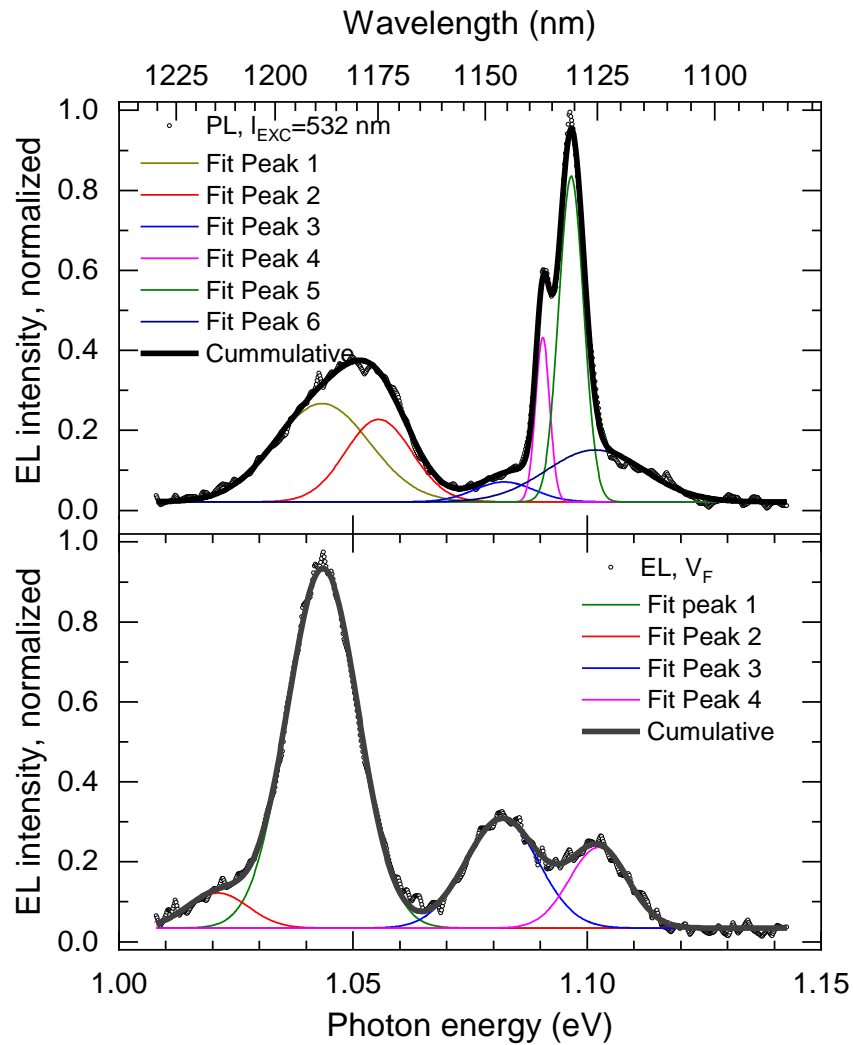
Appendix 1: TCAD modelling

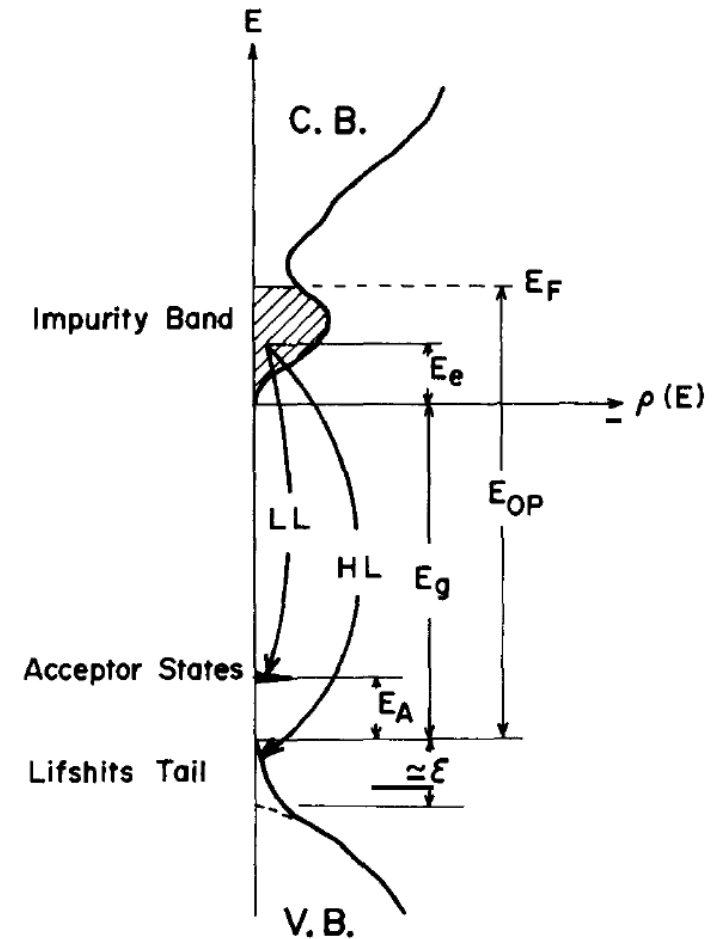
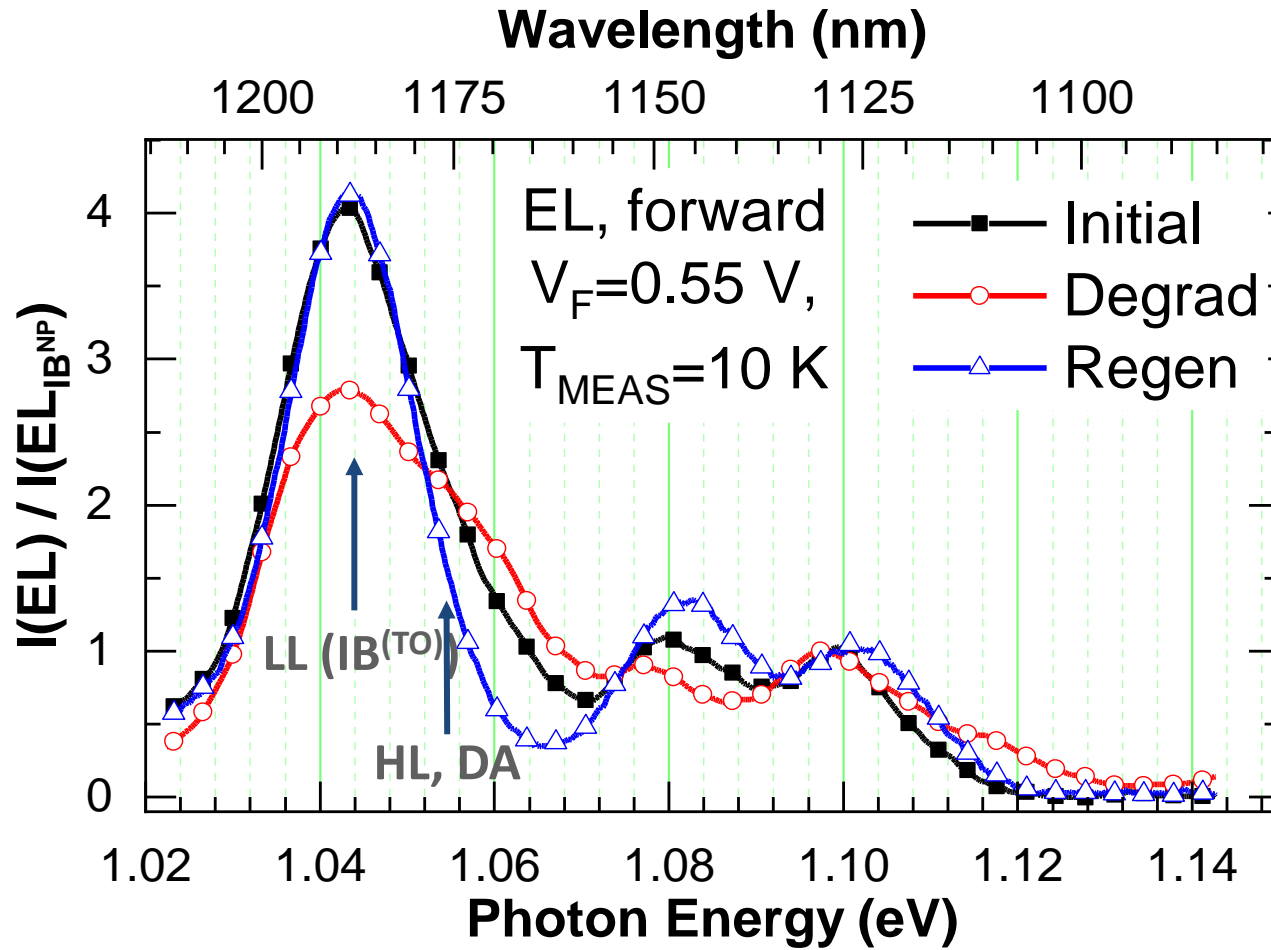
Forward bias: 0->690 mV
Operating: 550 mV

Reverse bias: 0-> -12 V
Operating: -12 V

Solving of equations	Poisson, Electron, Hole
Solver	Pardiso
T [K]	298.15
wafer	Boron doped
p_0 [1/cm ³]	9.74E+15
Phosphoros concentration at emitter described by Gauss -> peak value [cm ⁻³]	1.65E+20
wafer resistance [Ohm*cm] at 300 K	1.5
Surface recombination velocity of 1. holes and 2. electrons (fcont1ox?)	1E7; 1E7
Meshing with..	Box Method







[19] R.R. Parsons, 1979

